

Pixel 2010

An attempt of a summary ...

Norbert Wermes
Bonn University

... and apologies to those whose results
I forgot or had to decide to drop in this “summary“

20 years of pixels ... where are we now ? ... my view

the beginnings

first spin-offs → imag.
Xray, counting/integr.

DESY/SLAC
XFELs

LHC exp.
R&D

ILC
R&D

build
LHC det's

LHC det
ready

time
for

1990

2000

2010

new
dev'
mnts

hybrid
pixels

new
(semi) monolithic
approaches
DEPFETs
CMOS APS
CCDs

large Xray
detectors
PILATUS

new
CMOS
poss
SOI, 3D

real det's
with monol.
pixels
STAR
Belle2

The **new** challenges

❑ Very high rates (i.e. sLHC)

→ **need hybrid technology → 3D integration ?**

→ **issues**

- **radiation hardness and badwidth**
- **material**
- **size (area) → comp. materials**

❑ Somewhat lower rates (RHIC, SuperKEKB)

→ **MAPS, DEPFET, etc.**

→ **issues**

- **complicated (but smaller) detectors**
- **very low material budget**

❑ Imaging (Xray, synchr. light)

→ **from light sources → XFELs**

→ **issues**

- **large photon flux → dyn. range**
- **large frame rates**
- **homogeneous response**

Rate and radiation challenges at the innermost pixel layer

Hybrid Pixels

	BX time	Particle Rate	Fluence	Ion. Dose
	ns	kHz/mm ²	n_{eq}/cm^2 per lifetime*	kGy per lifetime*
LHC ($10^{34} \text{ cm}^{-2}\text{s}^{-1}$)	25	1000	1.0×10^{15}	790
sLHC ($10^{35} \text{ cm}^{-2}\text{s}^{-1}$)	25	10000	10^{16}	5000
SuperKEKB ($10^{35} \text{ cm}^{-2}\text{s}^{-1}$)	2	400	$\sim 3 \times 10^{12}$	50
ILC ($10^{34} \text{ cm}^{-2}\text{s}^{-1}$)	350	250	10^{12}	4
RHIC ($8 \times 10^{27} \text{ cm}^{-2}\text{s}^{-1}$)	110	3,8	1.5×10^{13}	8

Monolithic Pixels

lower rates
smaller pixels
less material

assumed lifetimes:
LHC, sLHC: 7 years
ILC: 10 years
others: 5 years

Pixel 2010, Sept 10, 2010 – NW, Bonn



First impression from PIXEL 2010 on Monday ...

The **big** LHC detectors are marvelously working



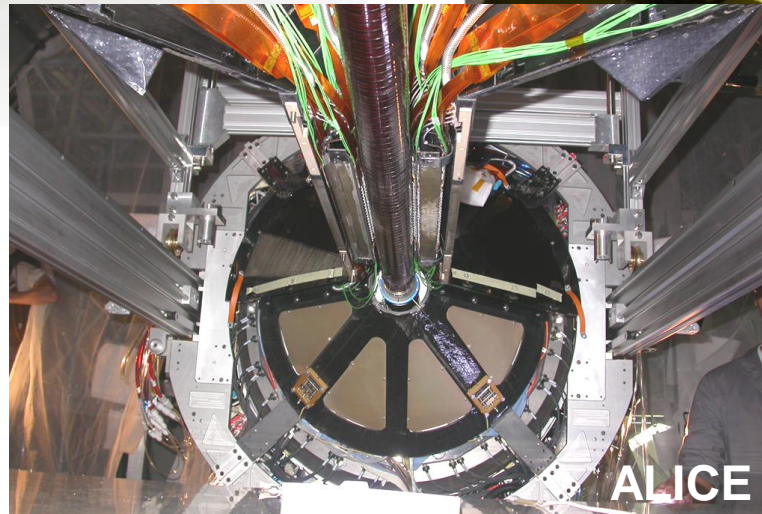
ATLAS

Joshua Moss
Markus Keil
Lidia Dell'Asta



CMS

Gino Bolla
Ben Kreis
Urs Langenegger

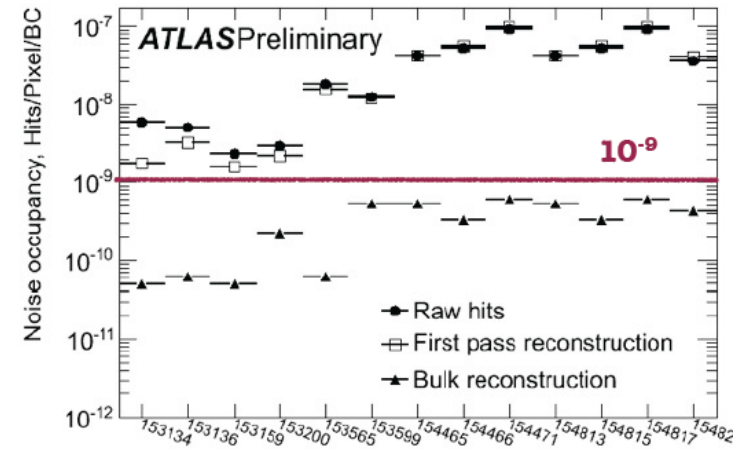


ALICE

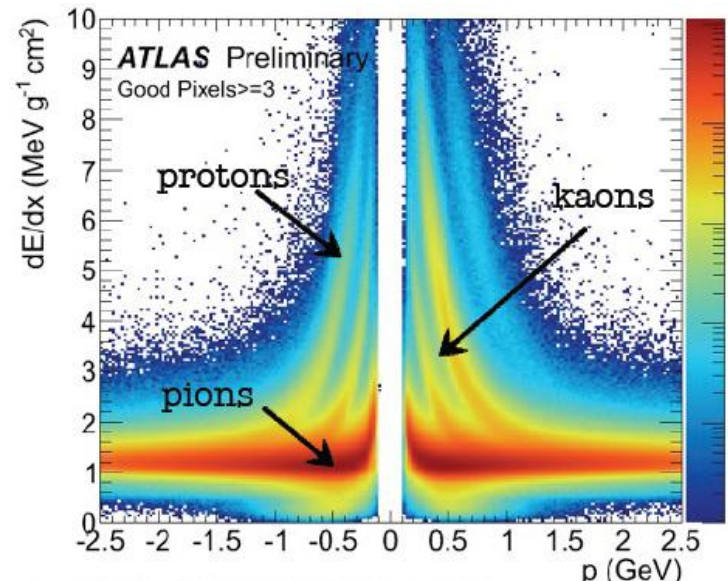
Petra Riedler

... the big LHC detectors

- essentially **noiseless**
< 0.2 noise hits per event (after masking) \Rightarrow
- high trigger rate cap. (to 80 kHz)
@ modest thresholds ($\geq 3000 e^-$)
high overall efficiencies ($\sim 99\%$)
(Ben Kreis, Markus Keil)
- excellent charge resolution \Rightarrow
- **bad**: material in ATLAS & CMS
 - >3% x/X_0 per layer
 - operation < 0° C
 - hybrid technology
 - first of their kind (parallel powering, copper, ...)



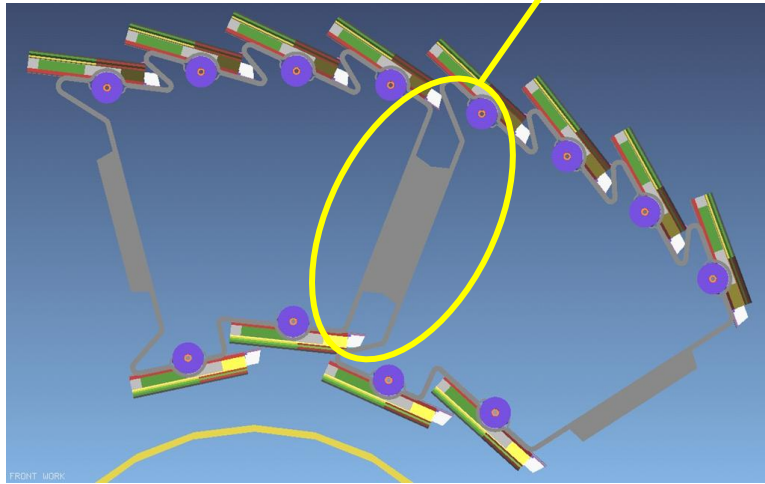
Lidia Dell'Asta



except ALICE ...

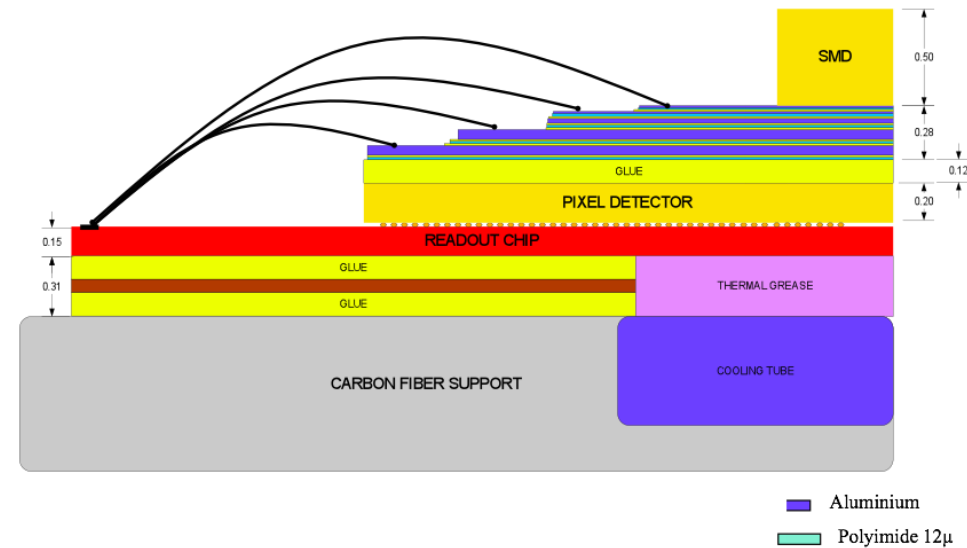
1.1 % x/X_0

not counted !



but also ...

- 1.75 cm² chip with bumps → 150 μm !
- sensor 200 μm !
- advanced Al flex !



because heavy ion collisions can afford

- to not have homogeneous coverage
- to operate at room temperature ($L \sim 10^{27} \text{ cm}^2 \text{ s}^{-1}$)
- to repair (have a bit easier access)

Petra Riedler

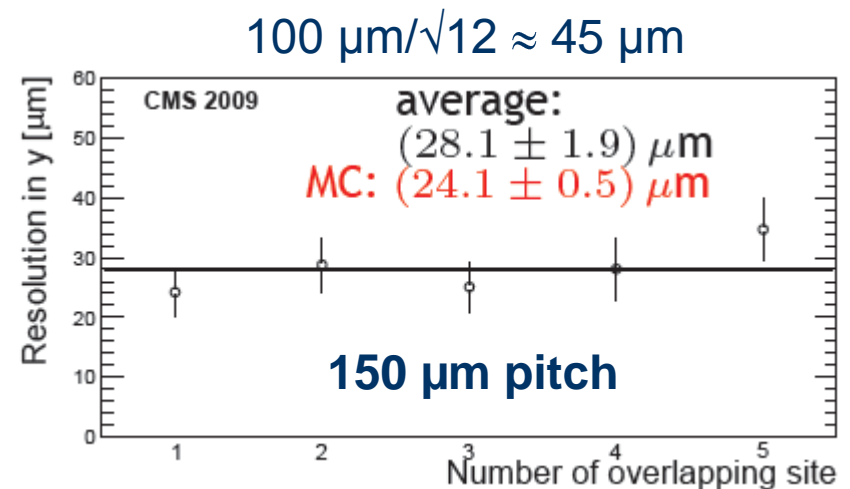
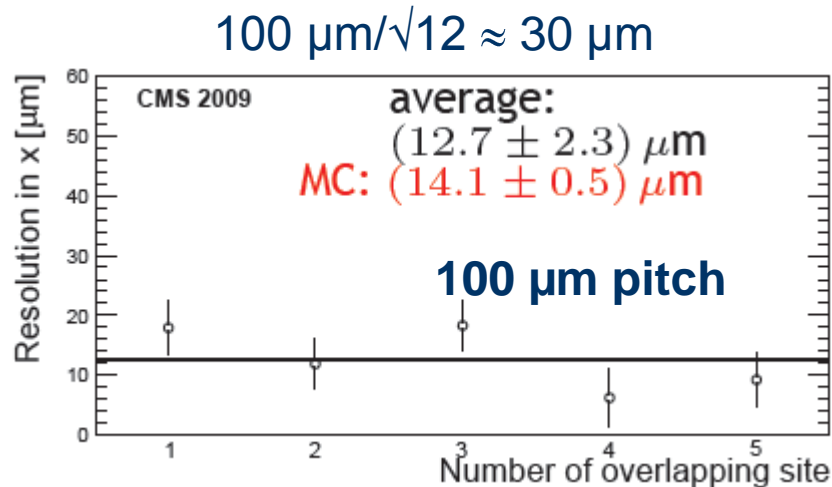
... and ... something to think about ... spatial resolution

ATLAS ☐

CMS ☐

- need decide ... **little** (more signal after rad.) or **more charge sharing** (better interpolation) tune by Lorentz angle and module tilt
- ATLAS: 25 μm (quoted incl. tracking error) will become $< 10 \mu\text{m}$ with 50 μm pitch
CMS: 12.7 μm with 100 μm pitch !!

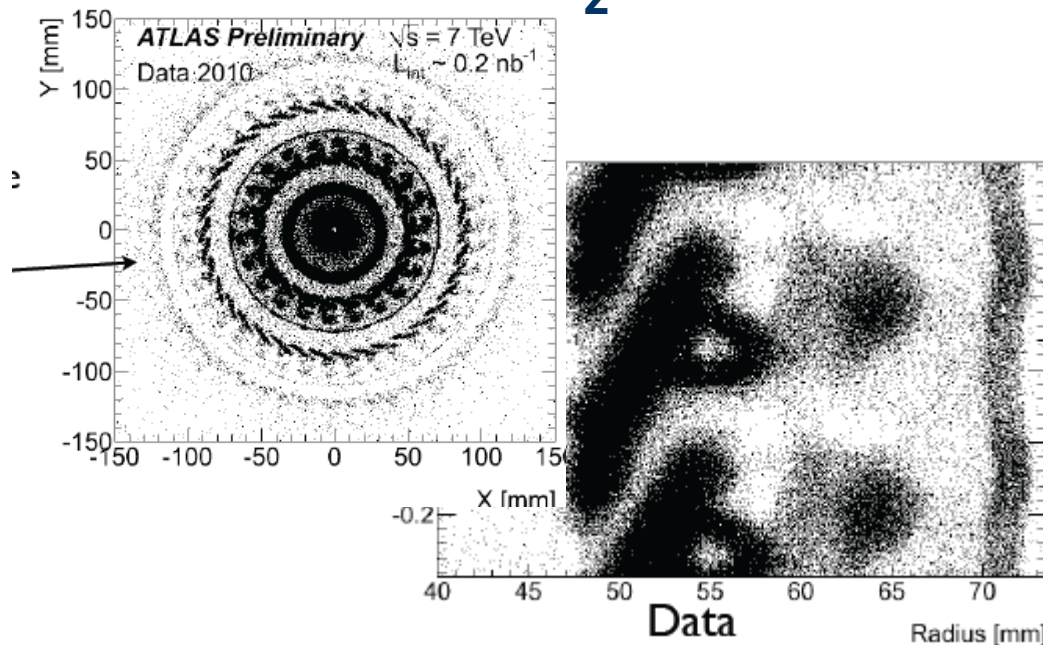
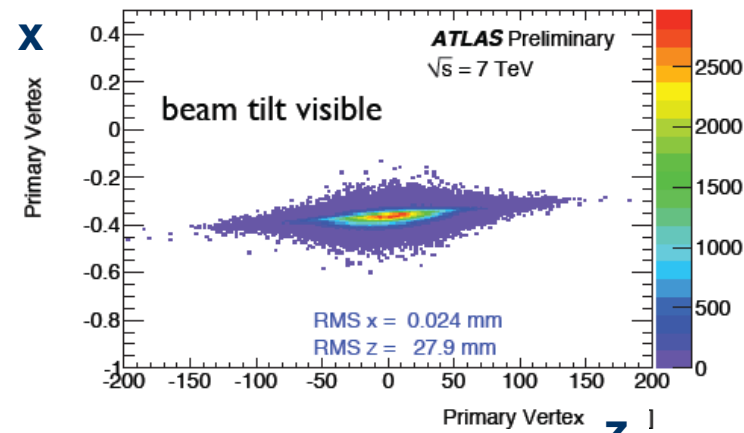
Urs Langenegger



CMS will pay when radiation damage requires more V_{bias} (also demonstrated by **Tilman Rohe**): higher field, less mobility, less Lorentz angle \rightarrow less charge sharing

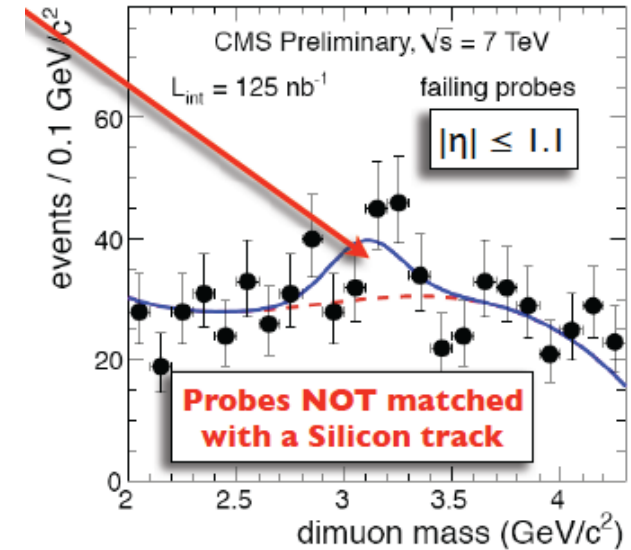
... and the data are beautiful

ATLAS: Florian Hirsch

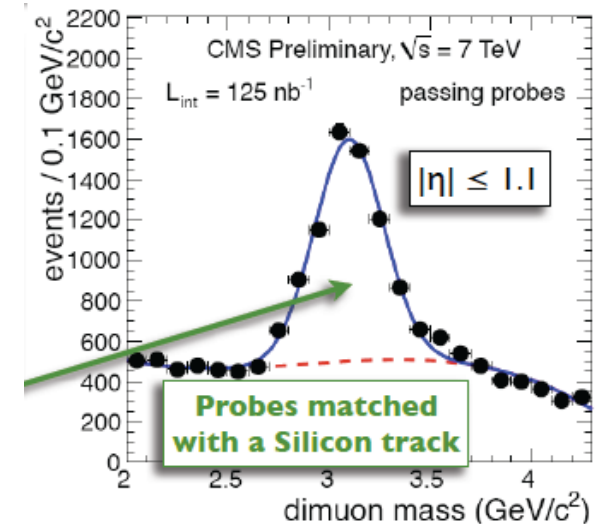


w/o tracker

CMS: Mauro Dinardo

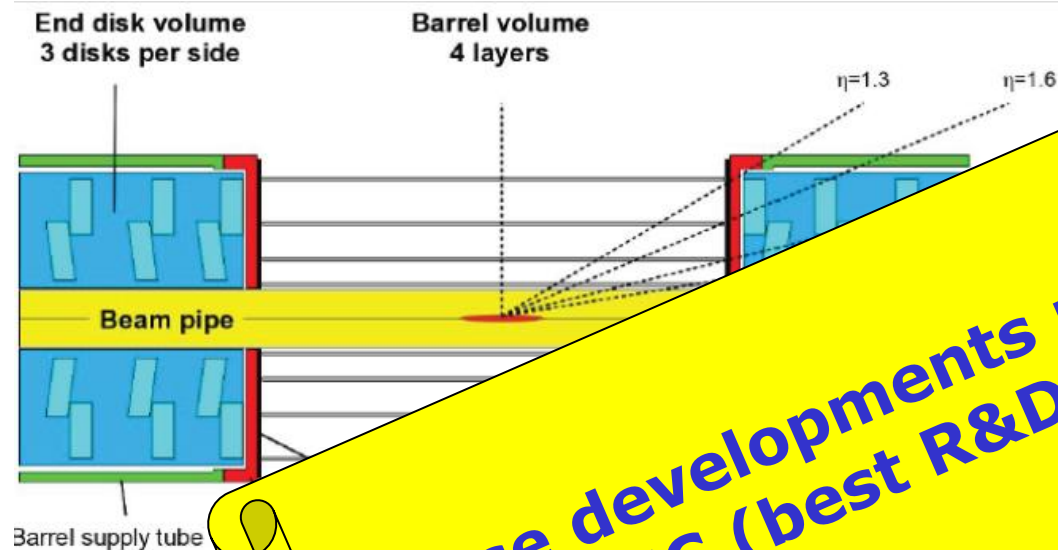


with tracker



... get ready for upgrades and sLHC

- must be hybrid pixels again (rate and radiation)
- **work on material budget !**

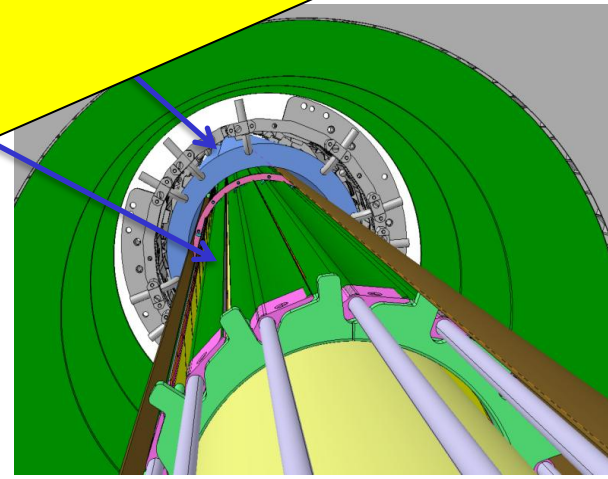
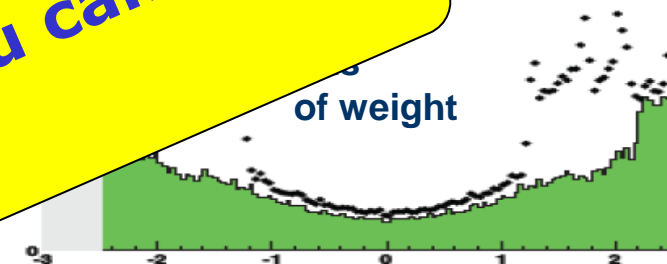


These developments pave the way for sLHC (best R&D you can do)

Alice Bean
Fabian Hügging

CMS

ers, 3 new disks
(re buffers)
and structure

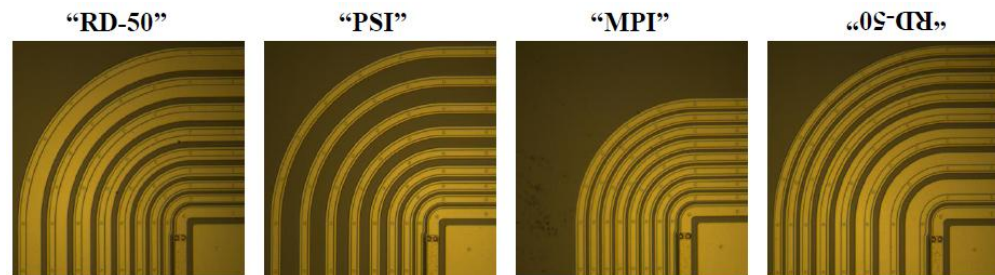


ATLAS

insert new innermost layer
FE-I4 chip ready ($> 2 \text{ cm}^2$)
light weight structure
new sensor types
extreme IC thinning
 $\rightarrow 1.5 \% x/X_0$

... which **sensor** to take best?

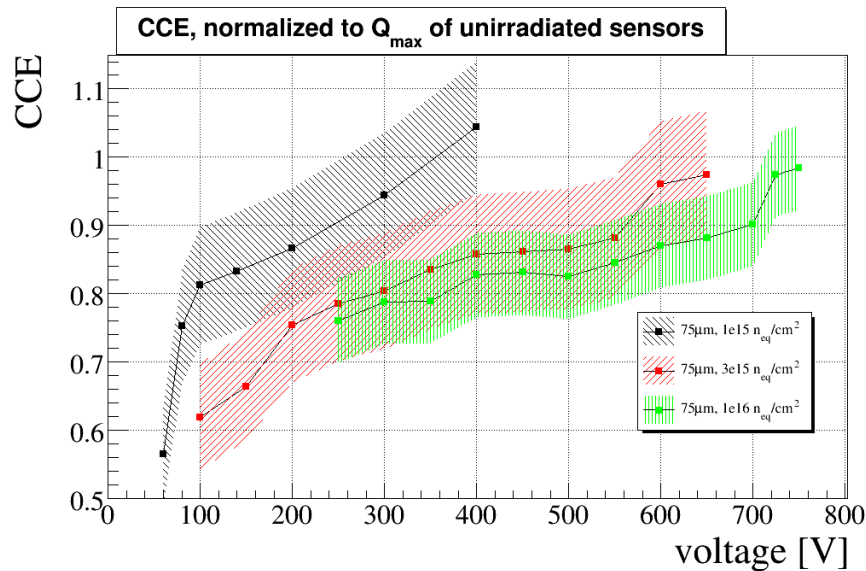
- **CMS:** use the same type (planar n in n) as used so far but take care of resolution degradation (**Tilman Rohe**) ... perhaps consider 3D (**Enver Alagoz**)
- **ATLAS:** study
 - thin planar n in n CiS (**Daniel Münstermann**)
 - thinned planar n in p (SOI process) (**Anna Macchiolo**)
 - thin planar n in p Hamamatsu (**Nobu Unno**)
 - planar n in p Micron (**Ilya Tsurin**)
 - various (slim) guard ring schemes



- 3D sensors (**Andrea Micelli**)
- diamond sensors (**Matt Hollingsworth → telescope**)
- **The issues:** **planar:** best understood, cheaper (specially n in p), needs very high voltage after high irradiation
3D: lower drift distance, low V_{dep} , large active area, efficiency in column, capacitance/noise, production yield
diamond: low C, no i_{leak} , exc. therm. prop., ... can one make them in

large quantities?

... planar or 3D silicon

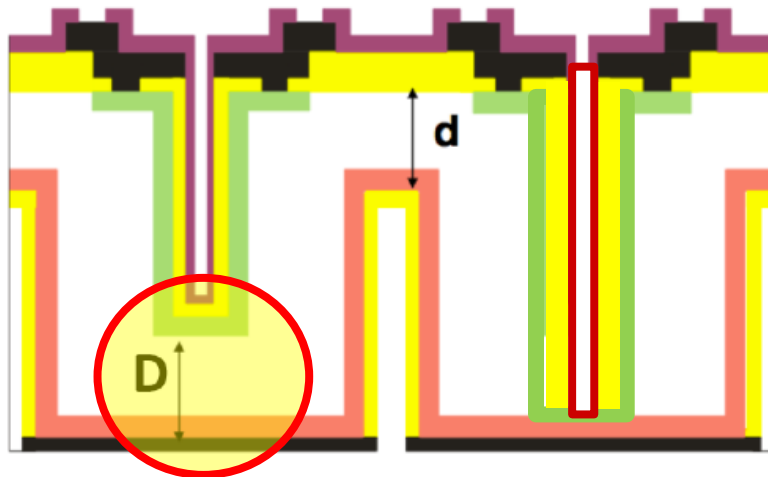


Anna Macchiolo

thin (75 μm) planar Si sensors seem to stand $10^{16} \text{ n}_{\text{eq}}/\text{cm}^2$ with little loss of CCE at not too prohibitive voltages probably due to charge multiplication
... but is 6000 e^- enough?

FBK/CNM

Stanford/SINTEF



Andrea Micelli

columns **through** or **not through** ?

inefficiency for straight tracks

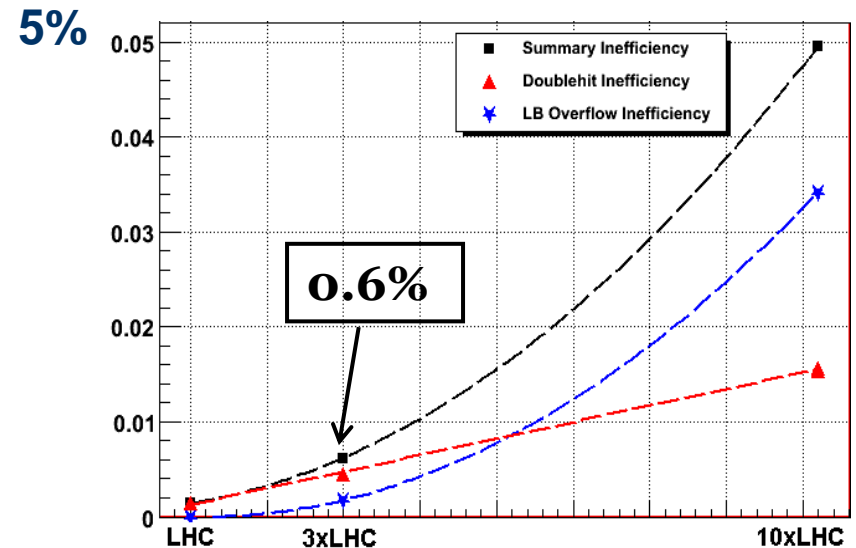
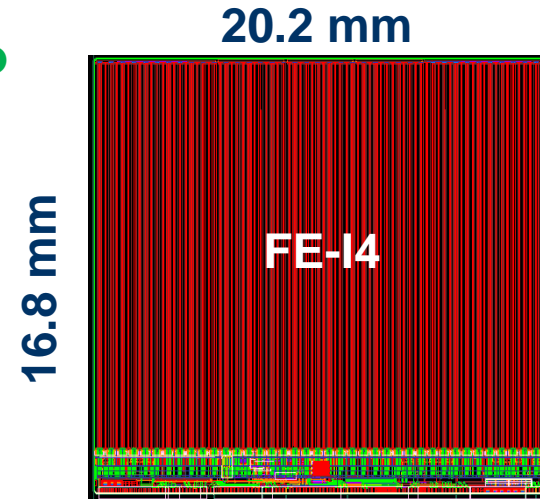
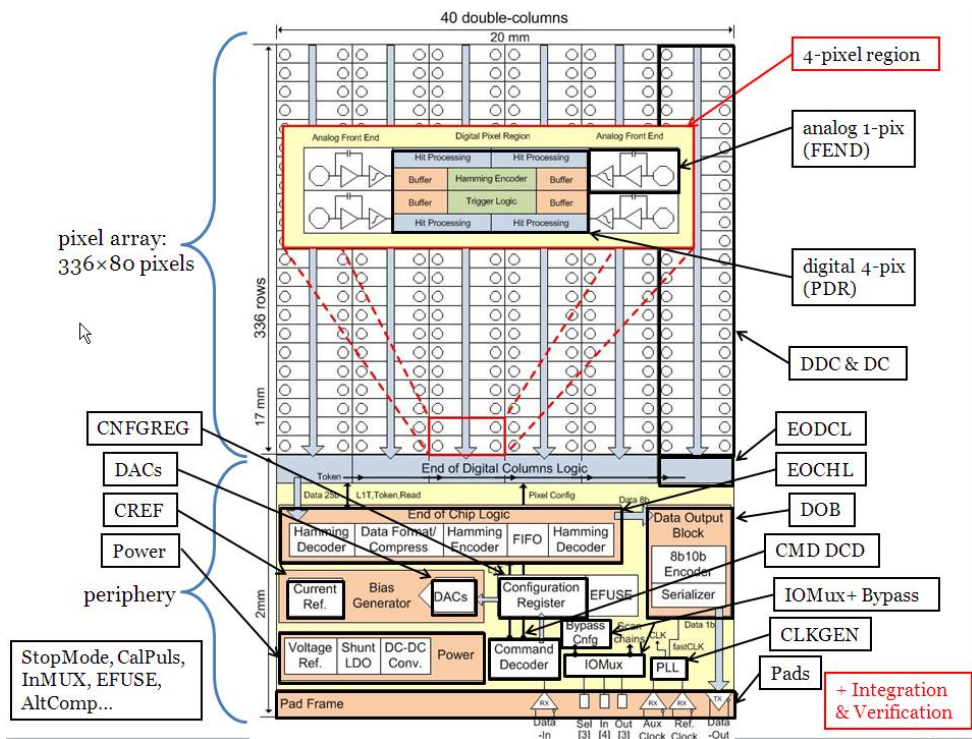
leaves depleted part under column, but region of inhomogeneous fields

note: tracks are inclined
still: have to establish reliable production

... new tricks ... to cope with high luminosity

FE-I4 Chip for ATLAS pixels Marlon Barbero (large design effort, several groups)

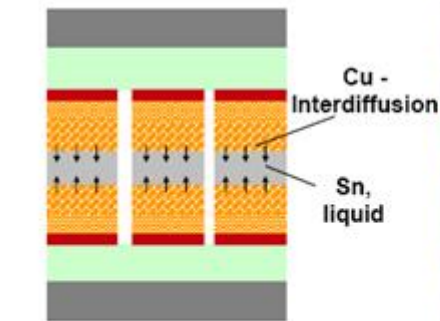
many gadgets:
local hit storage until trigger
better clustering info
use against time walk ...



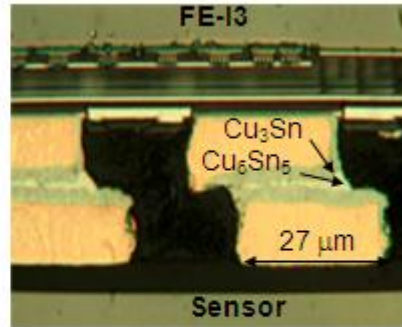
CMS: new chip in planning, more buffers
less vulnerable for losses in column drain

... aggressive addressing of the material budget

exploit: 3D integration for hybrid pixels, through silicon vias, wafer to wafer connection



Contact under Pressure and Heat
~ 5 bar, 260 – 300 °C (Sn-melt)



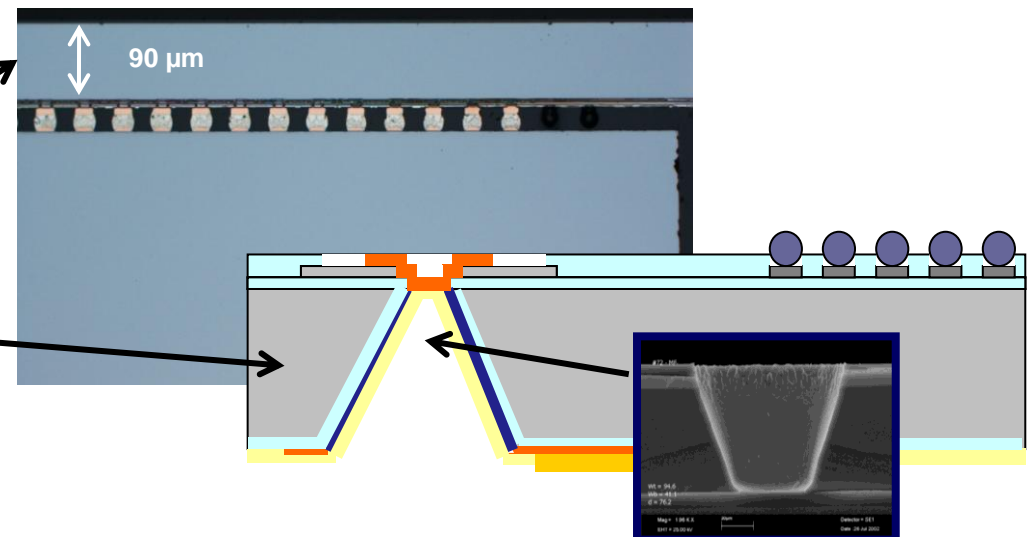
Formation of Eutectic Alloy;
 $T_{\text{melt}} > 600\text{ °C}$

SLID
(IZM Munich)

Anna Macchiolo

gain ~ 1% x/X_0 in ATLAS with

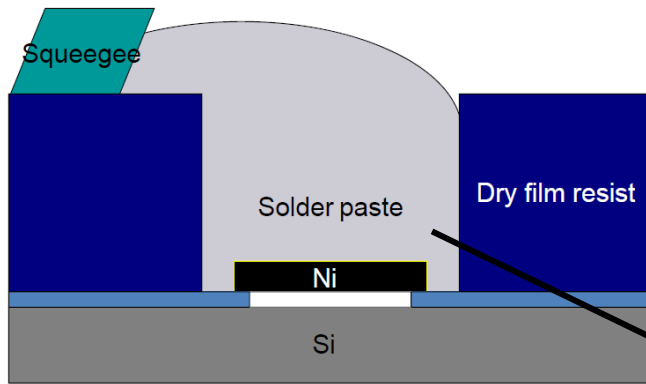
- 90 μm bumped FE-I4 chip
- thin Al flex
- serial powering
- TSV and backside metal routing



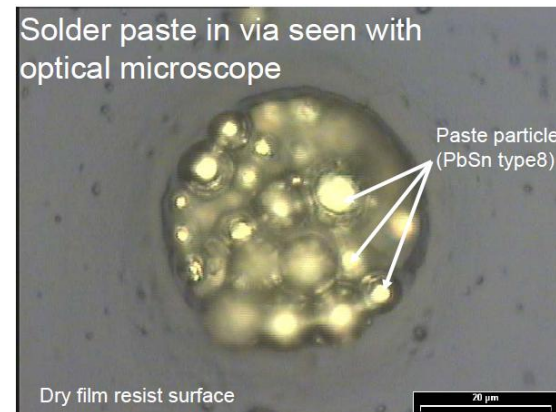
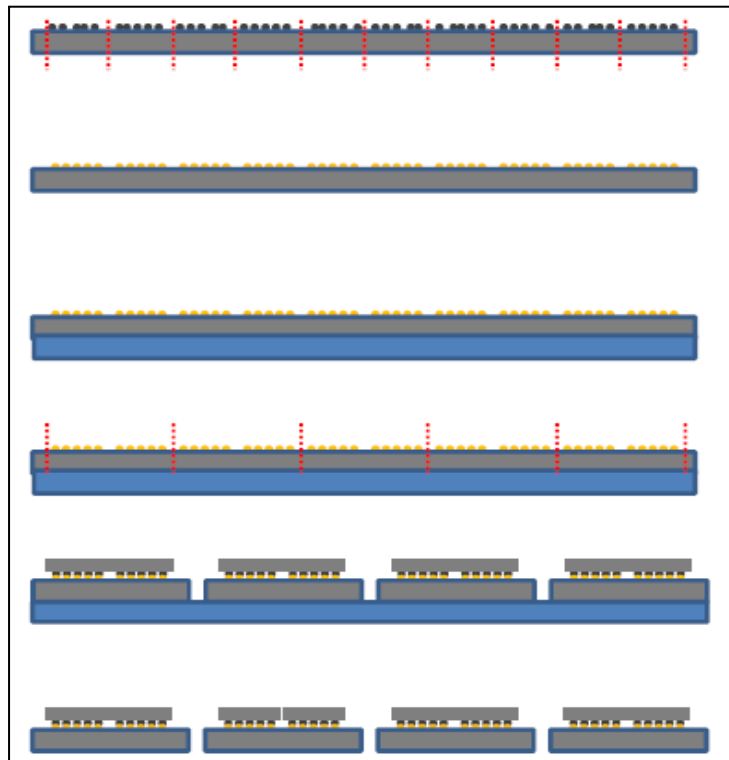
Laura Gonella

... and **low budget** for large trackers, e.g. @ sLHC

Thomas Fritzscht



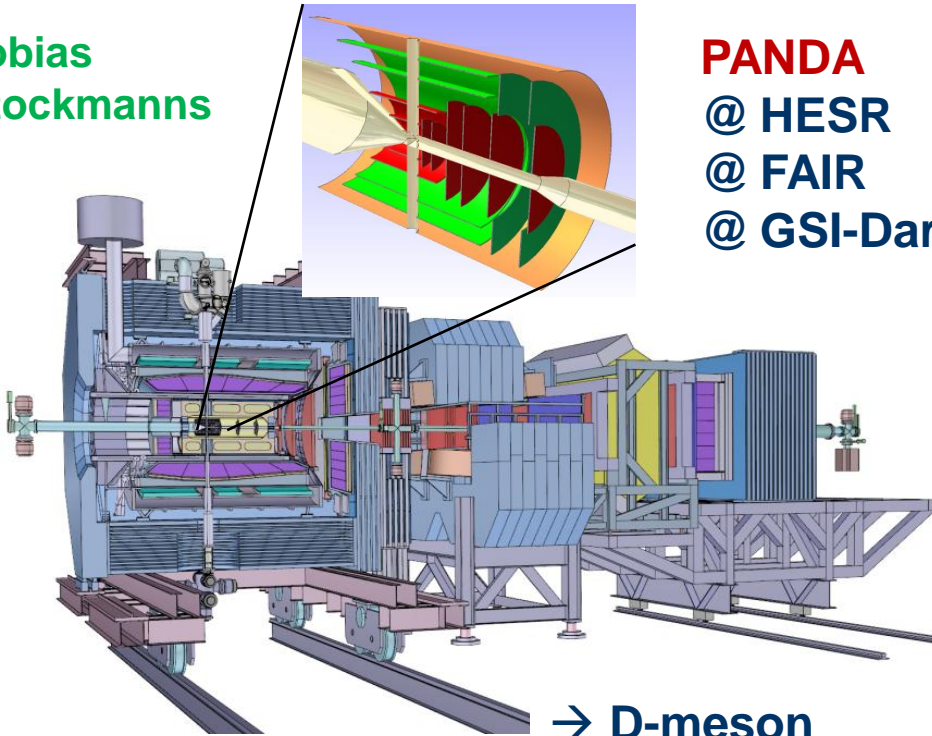
solder pasting (rather than electroplating)



chip to wafer FLIP-Chip assembly

... good experience in hybrid pixels ... now used elsewhere

Tobias
Stockmanns



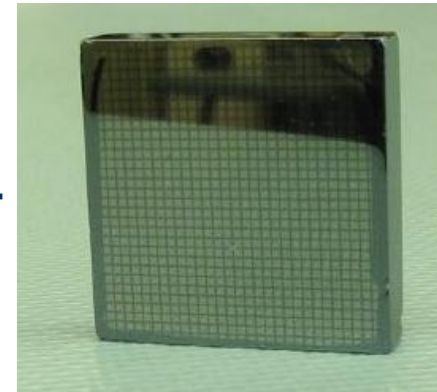
PANDA
@ HESR
@ FAIR
@ GSI-Darmstadt

Maria Schwenke

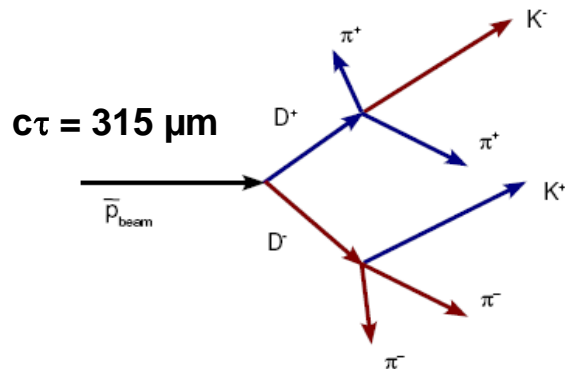
COBRA @ Gran Sasso



CZT



$0\nu\beta\beta$
search

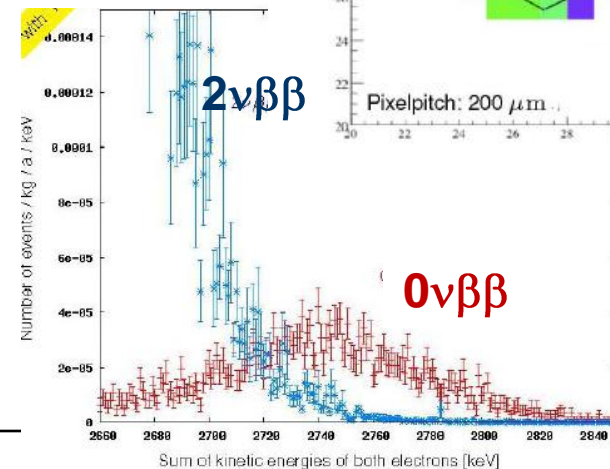


→ **D-meson
tagging**

<2% x/X_0
no trigger

→ **ATLAS-like modules**
dedicated chip
epi-Si

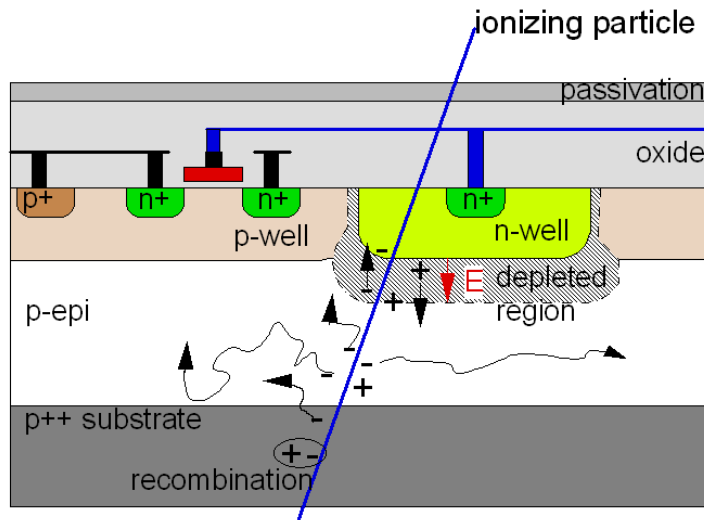
use ^{116}Cd



New generation semi-monolithic pixel detectors have become reality ...

... as **Vertex Detectors** in big experiments (both ready ~2013)

MAPS → STAR @ RHIC



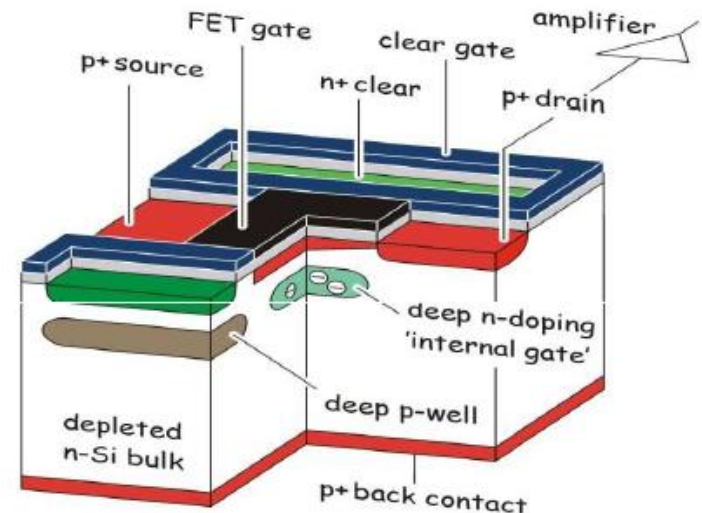
Q coll. in epi layer → small sig.
MOS circuitry in active area (low noise)

tot. area
0.16 m²

Leo Greiner
Andrei Dorokhov

- + no bump bonding
- + very thin (50 μm resp. 75 μm) → ~0.2% x/X_0
- + small pixels (20x20 resp. 50x50 μm^2)
- + low power → less cooling
- radiation hardness
- speed

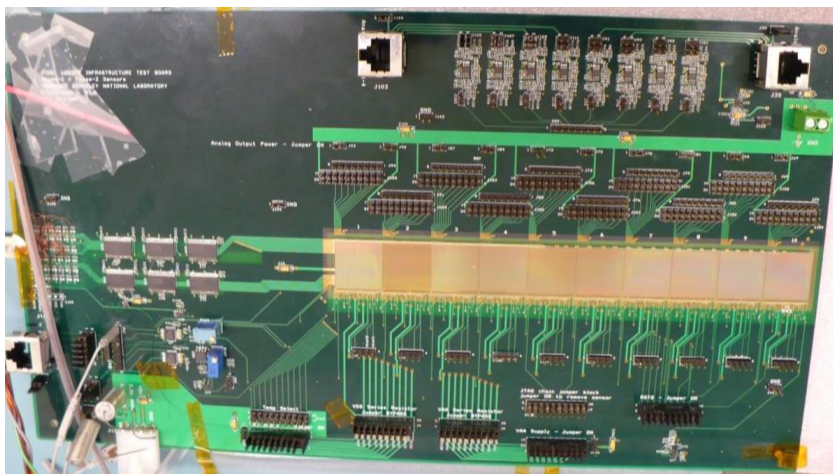
DEPFET → Belle 2 @ superKEKB



amplif. MOSFET in every pixel

tot. area
0.014 m²

Carlos Marinas



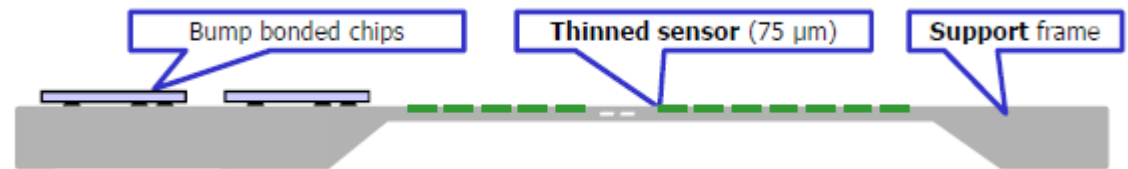
**TB with thinned 50 μm sensors
is ready for testing**

Pointing resolution	$(12 \oplus 19\text{GeV/p.c}) \mu\text{m}$
Layers	Layer 1 at 2.5 cm radius Layer 2 at 8 cm radius
Pixel size	$20.7 \mu\text{m} \times 20.7 \mu\text{m}$
Hit resolution	$6 \mu\text{m}$
Position stability	$6 \mu\text{m rms}$ (20 μm envelope)
Radiation length per layer	$X/X_0 = 0.37\%$
Number of pixels	356 M
Integration time (affects pileup)	$185.6 \mu\text{s}$
Radiation requirement	20 to 90 kRad 2×10^{11} to 10^{12} 1MeV n eq/cm ²
Rapid detector replacement	< 8 Hours

2-layer pixel vertex detector (PXD)

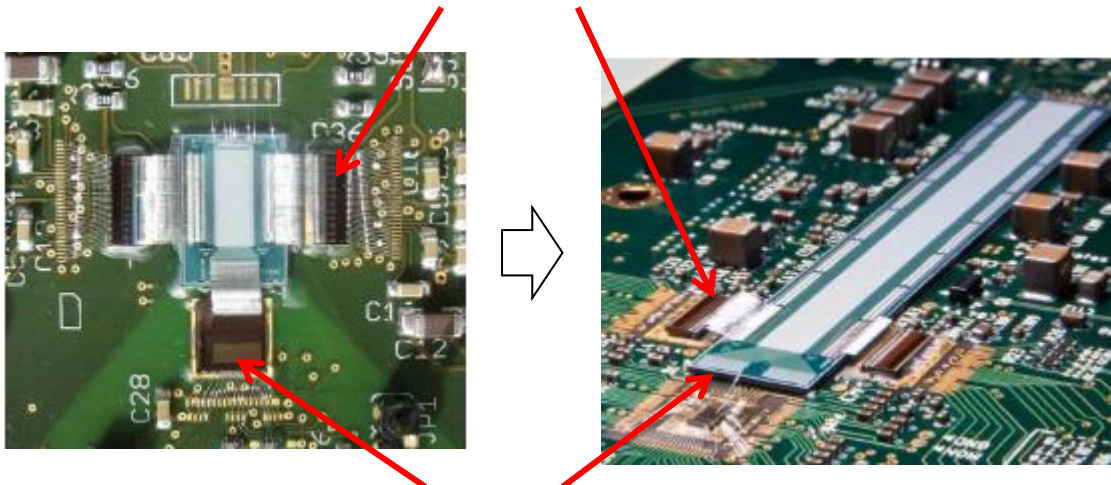


thinned by backside etching, leaving a frame

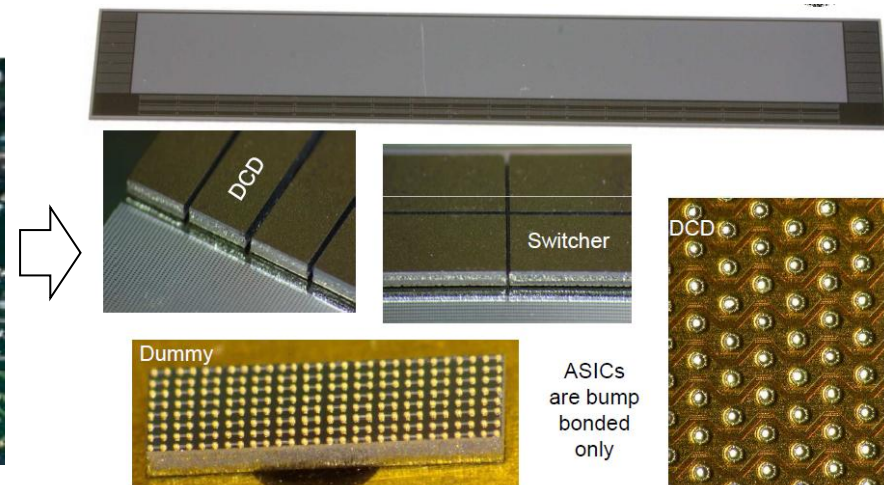


... on their way to the final module
sensor + switcher + DCD + DHP

ladder control ICs

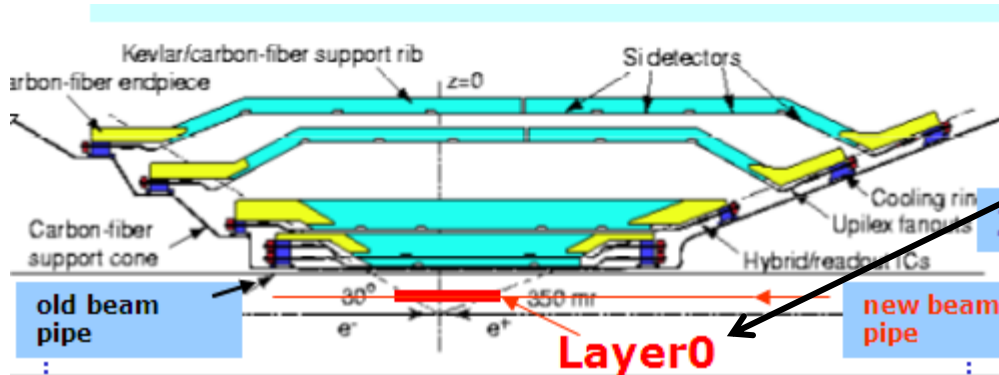


R/O ICs



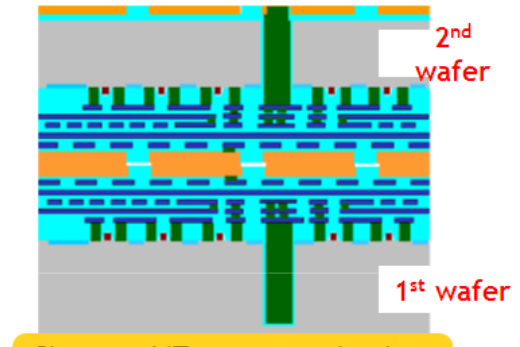
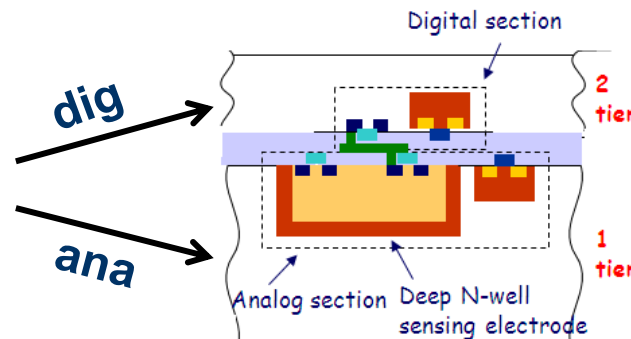
... and SuperB ...

Giuliana Rizzo



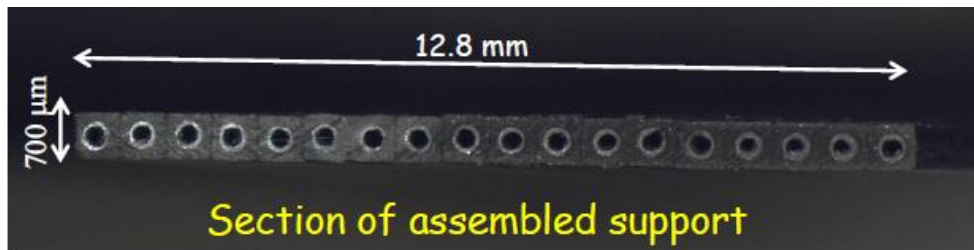
options
CMOS MAPS
 or
3D MAPS (2 tiers)
 or
3D hybrid pix (2 tiers)

3D – 2 tier - stack



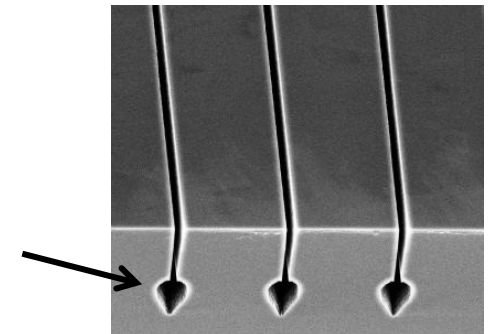
Filippo Bosi

$HTC \sim (\text{hydraulic diameter})^{-1}$

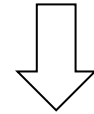
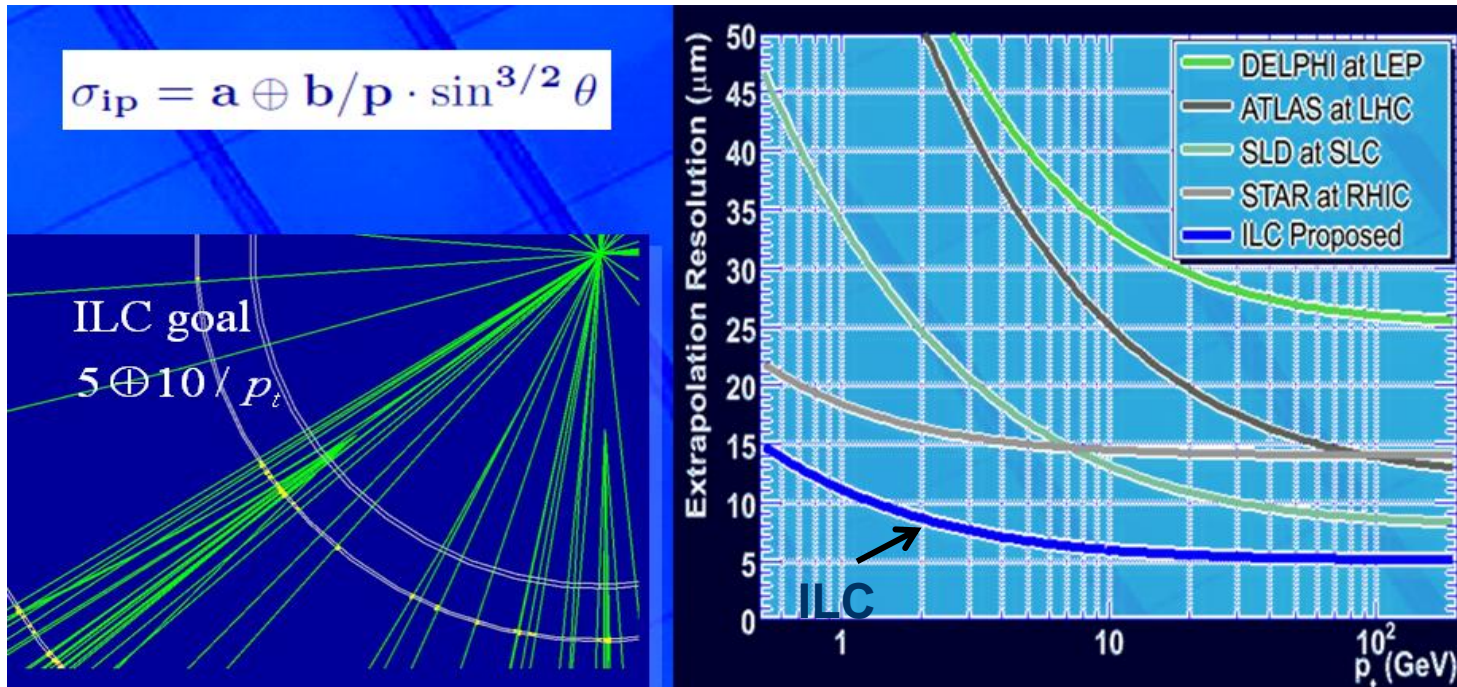


← **micro tubing
 micro channels**

**first experience
 encouraging**



... the best possible is just good enough to meet the goals

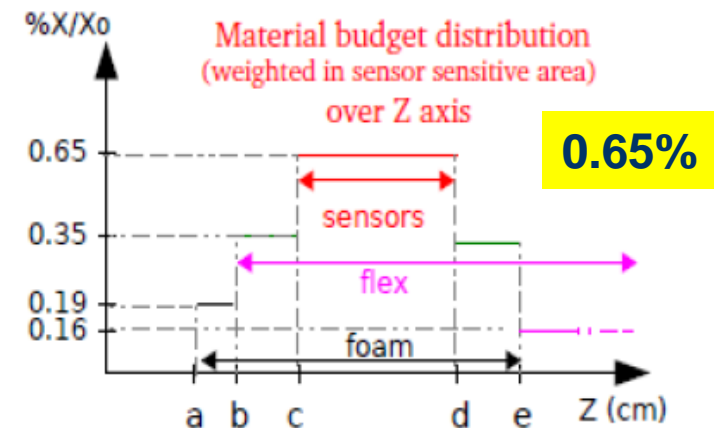
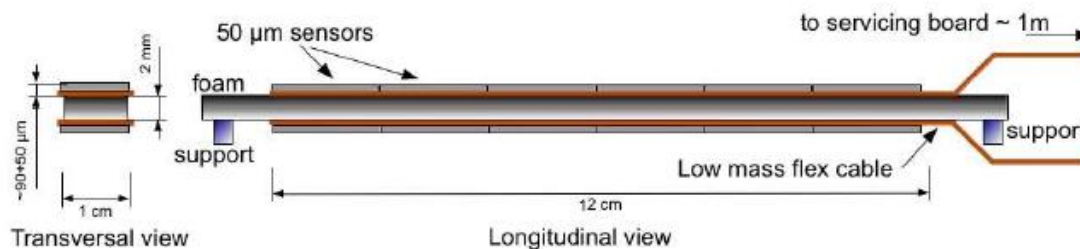


~50 μm Si thickness

0.1% x/X_0 per layer

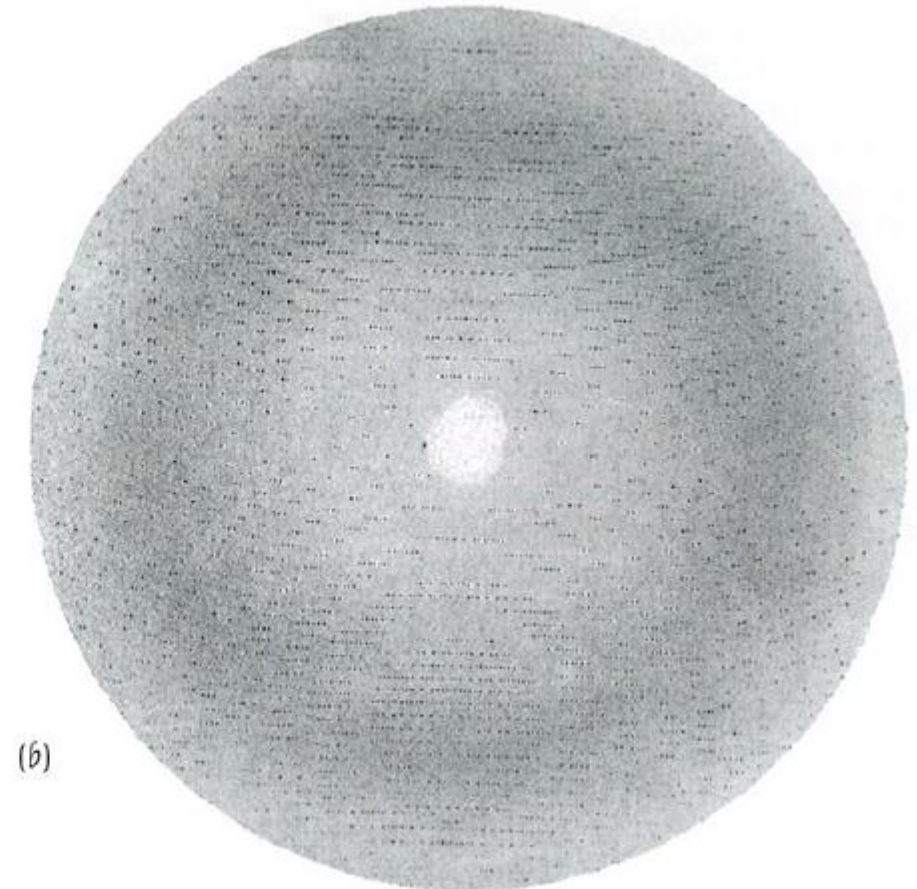
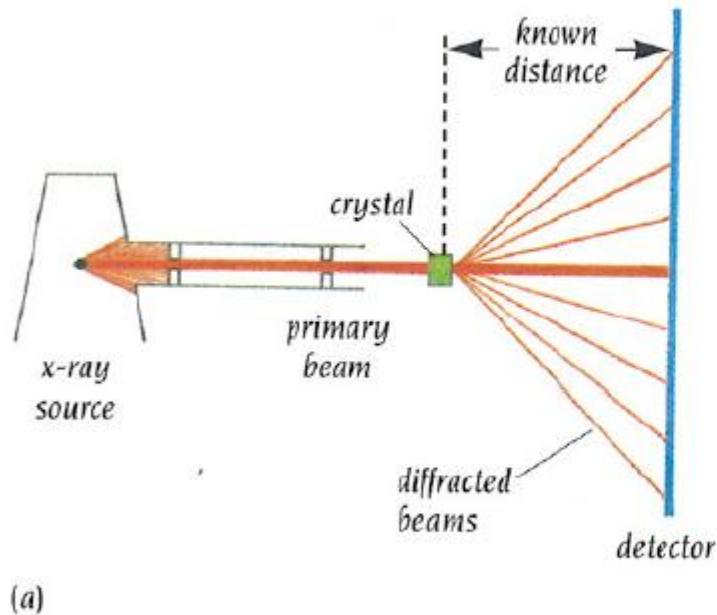
~2μm space res.

plume ladder (ultra light) (Andrei Nomerotski)



Imaging

... a big step in Synchrotron Light Imaging expts.



**Bragg pattern
derive the atomic e- density**

from Clemens Schulze - Bries

What they need ... from SL-sources to XFELs

(simplified)

- count rates per pixel > MHz
 - high frame rates (100 Hz – 10 kHz → 5 MHz)
 - huge dynamic range (1 photon to 10^6 photons)
 - pixel size < 50 μm
 - seamless detectors
 - “no” dead time
- **hybrid pixels with counting R/O chips** (as compared to Imaging Plates, CCDs, et al.)
have improved the imaging possibilities enormously.
- **pn frame CCDs** (first images at XFELs) → **DEPFET arrays**

Clemens Schulze - Briesse

PILATUS 6M

from 15-16 bit (CCD)
to 20 bit dynamic range



max. count rate ~ several MHz/pix
frame rate 12.5 Hz, 3ms dead time

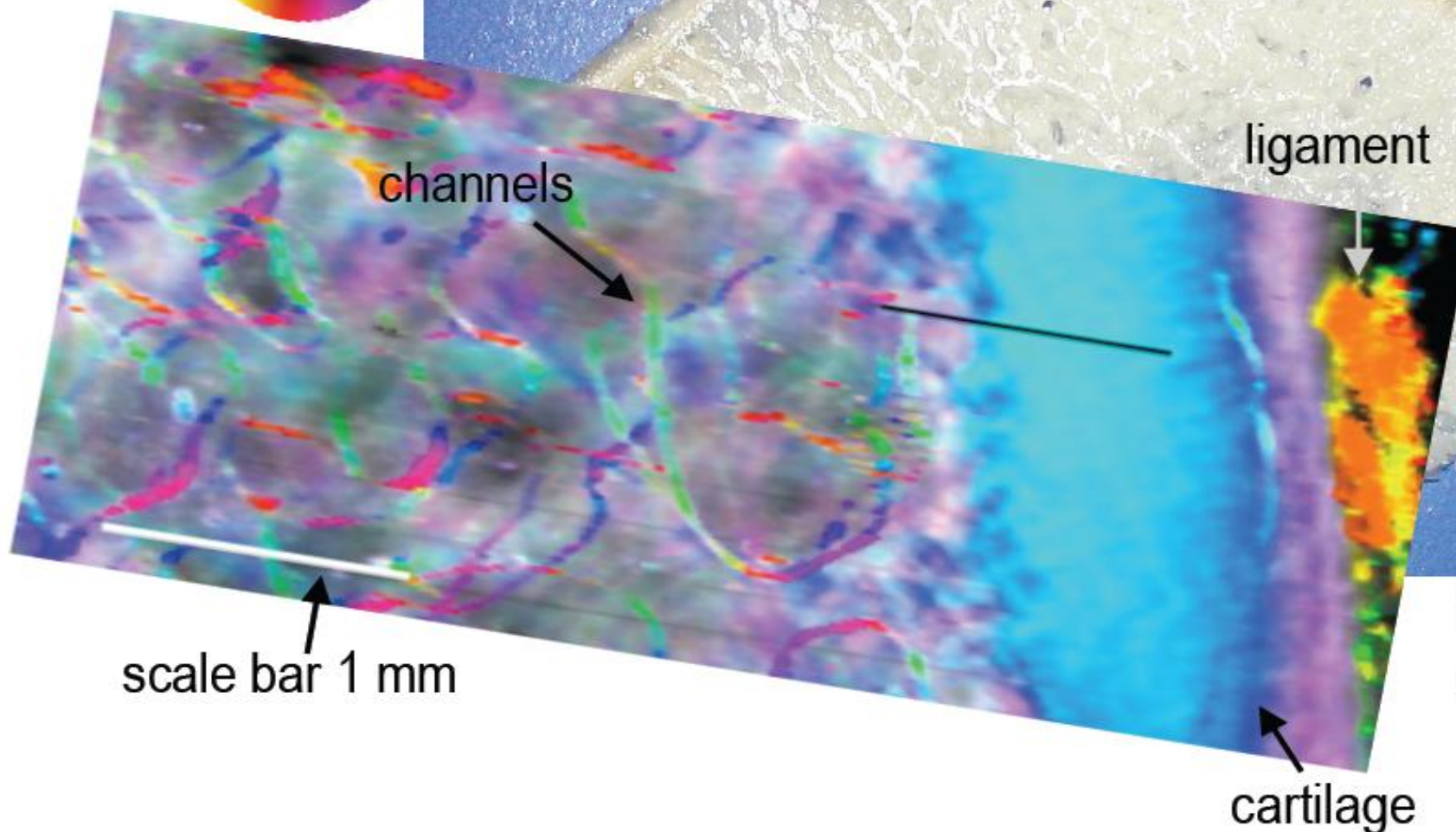
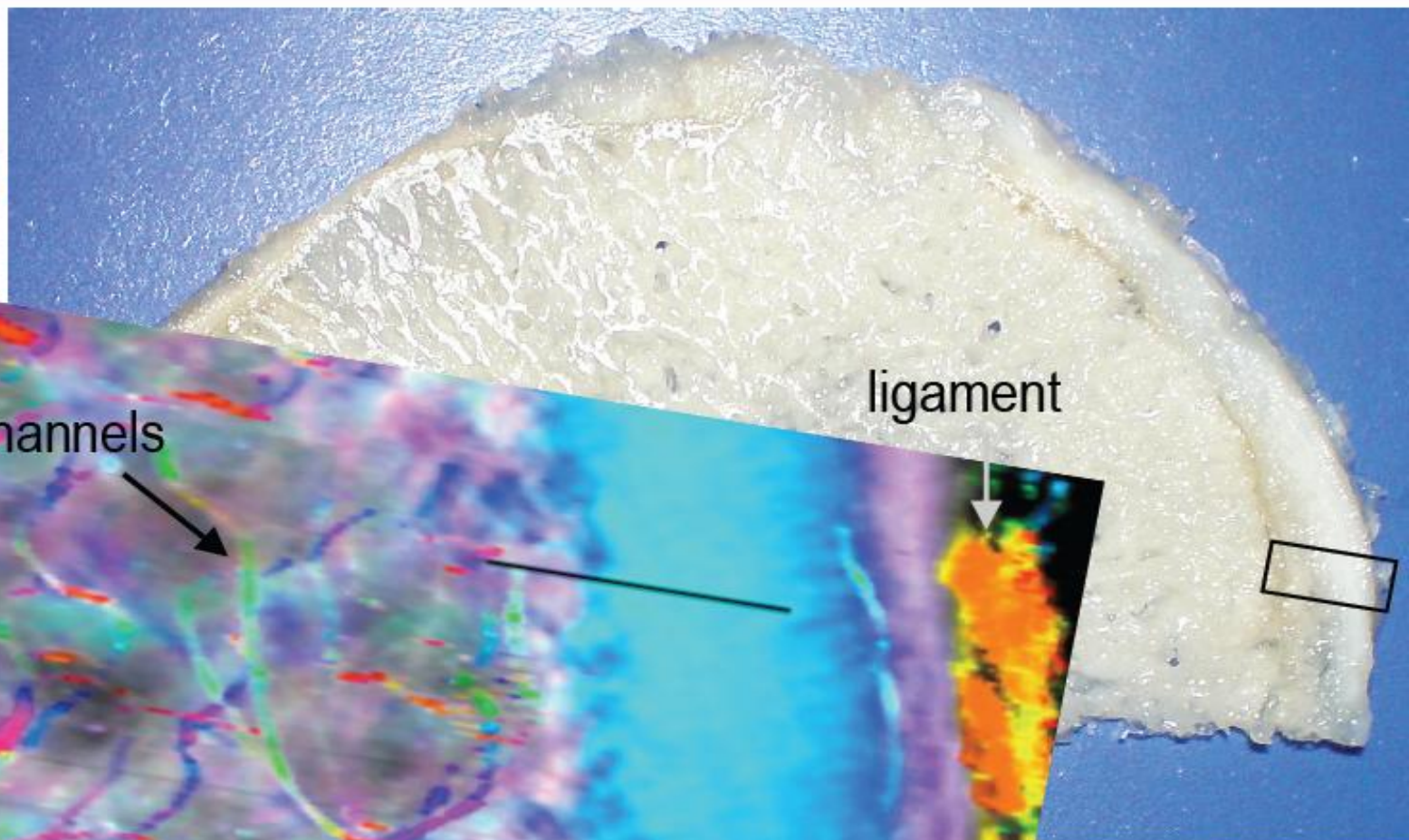
a number of important
new possibilities

- ⇒ Continuous shutter-free data acquisition
- ⇒ Fine φ -slicing in continuous mode
- ⇒ Possibility to take high redundancy, low exposure data
- ⇒ Simultaneous collection of low and high resolution data
- ⇒ Diffuse scattering experiments
 - T.Weber et al., J.Appl. Cryst. (2008), 41, 1
 - A. Bosak et al., PRL **103**, 076403, (2009)
- ⇒ Room temperature data collection with less radiation damage

Clemens Schulze - Briesse

Human femoral head: area with thick cartilage

colour codes
orientation

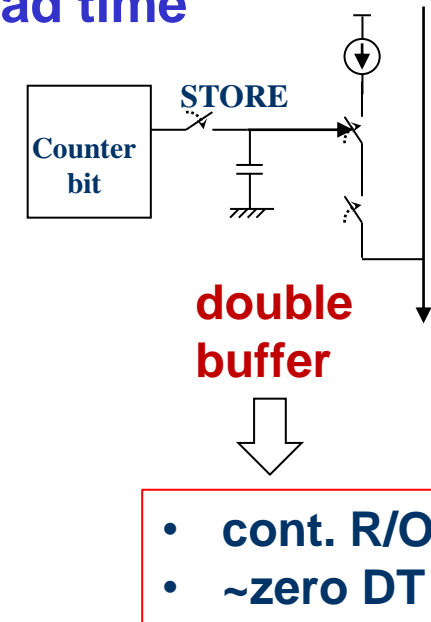
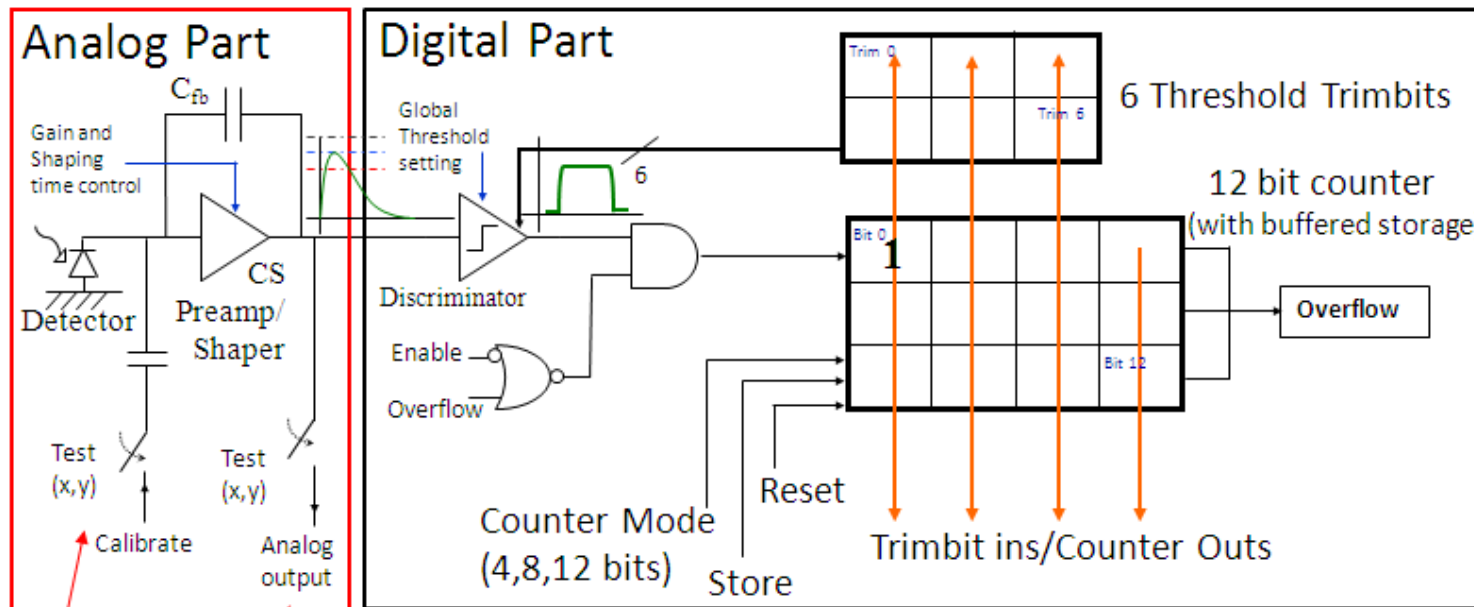


57 – 78nm
structures

The next generation **EIGER**

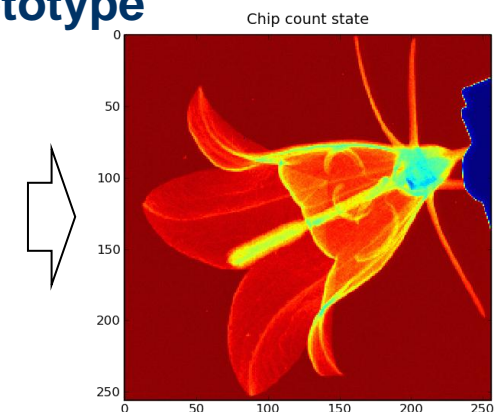
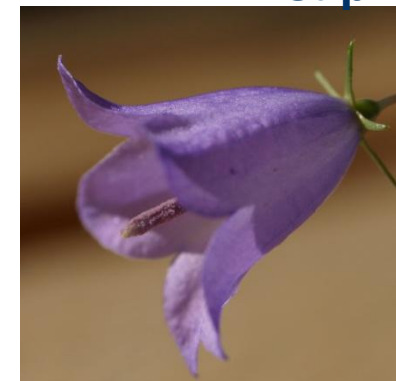
Roberto Dinapoli

→ smaller pixels ($75 \times 75 \mu\text{m}^2$) – larger frame rate – less dead time



EIGER Single Chip Detector

first prototype

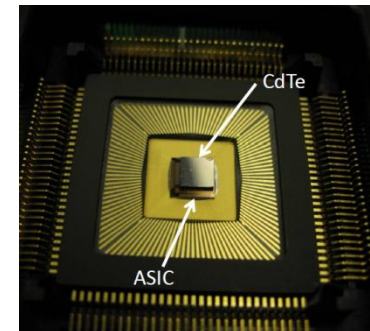


Spring-8 ... from PILATUS to CdTe ... E-selective ...



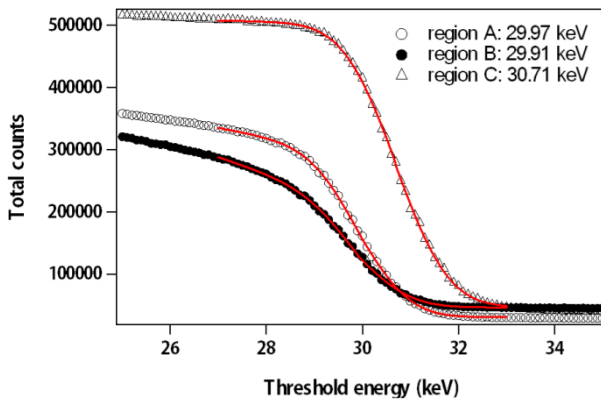
Toko Hirono

CdTe (for high absorption in >15 keV range)
+ window comparator
(low and high thresholds)



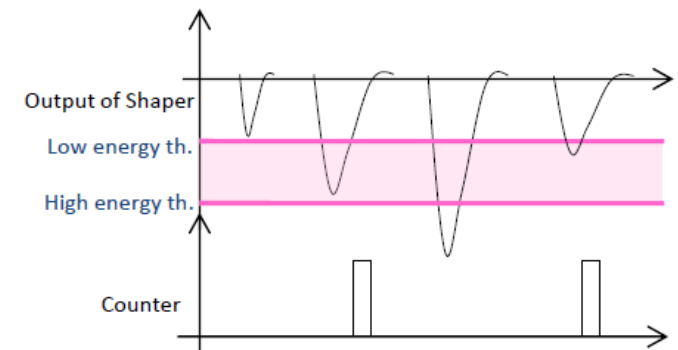
5x5 mm²

Schottky and ohmic CdTe devices



Hidenori Toyokawa

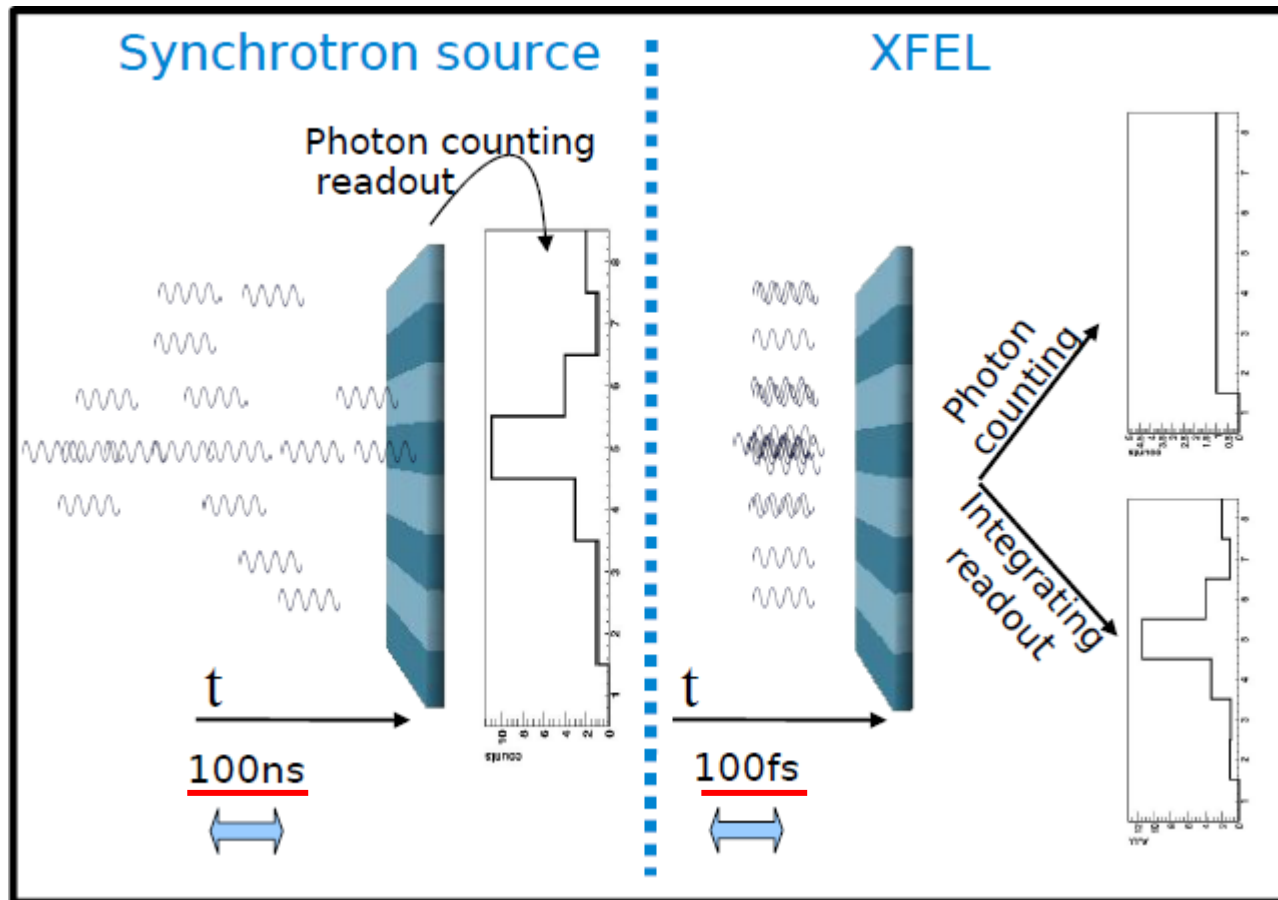
energy resolved
Xray imaging
by threshold
scanning



select an energy range

... next ... pixels for XFEL imaging

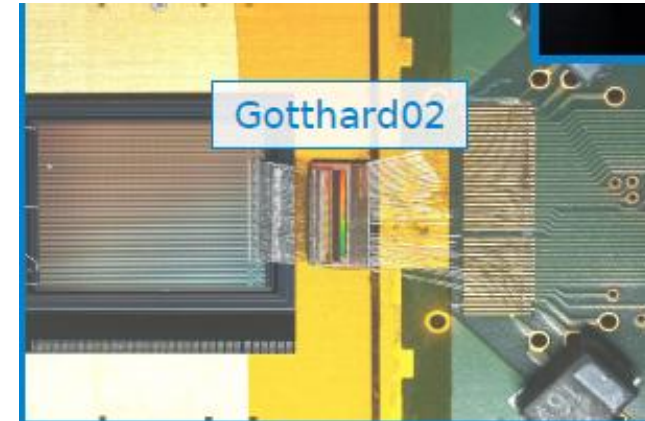
what is different ?



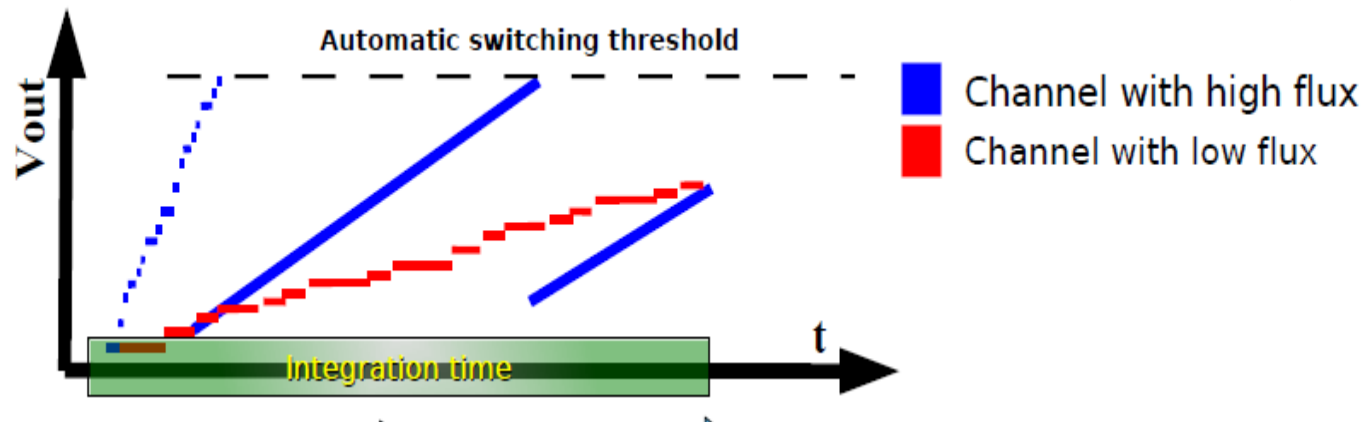
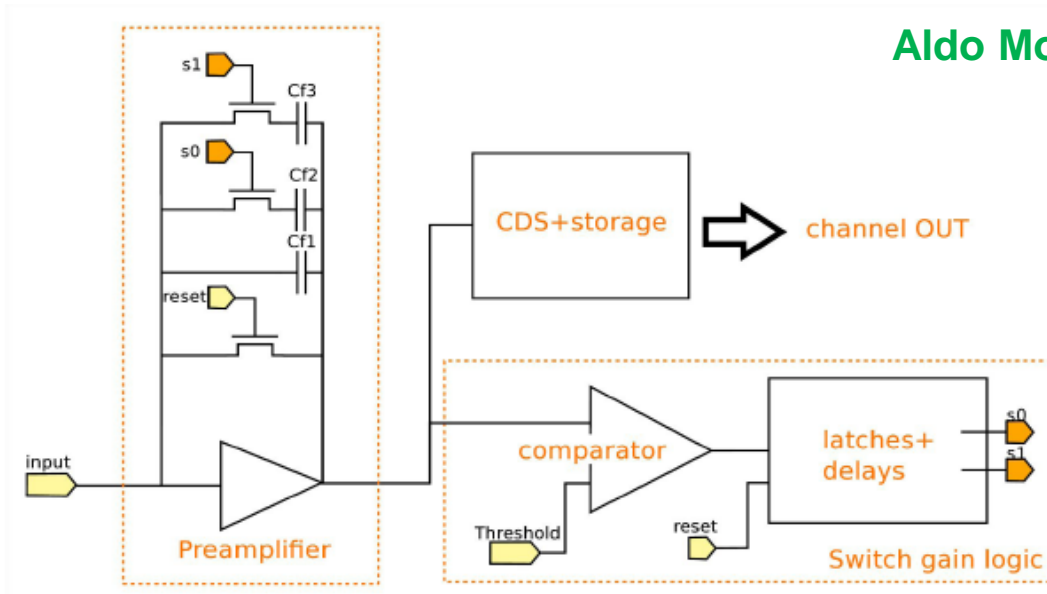
up to 10000 photons per pixel per bunch (200ns)
→ need **5 MHz** frame rate and
huge dynamic range

...how to cope ?

Aldo Mozzanica



Gotthard (strips)



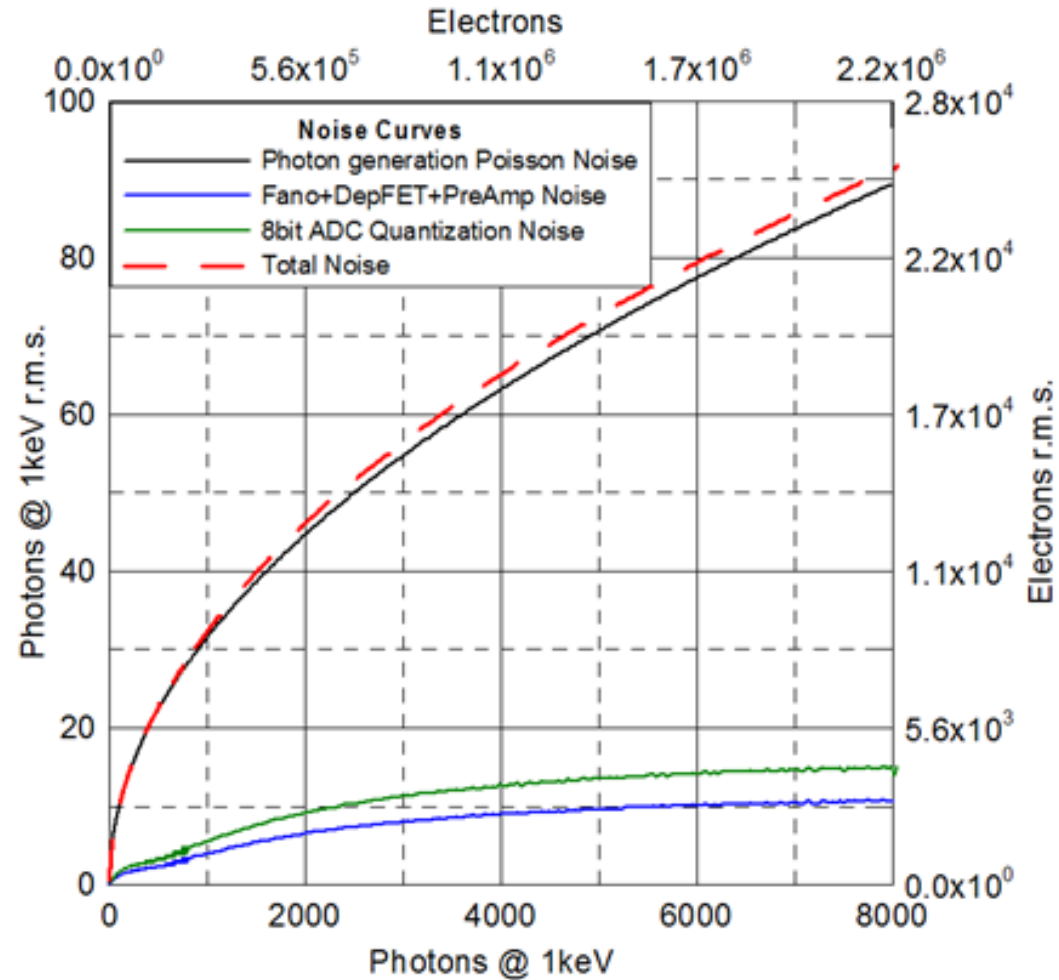
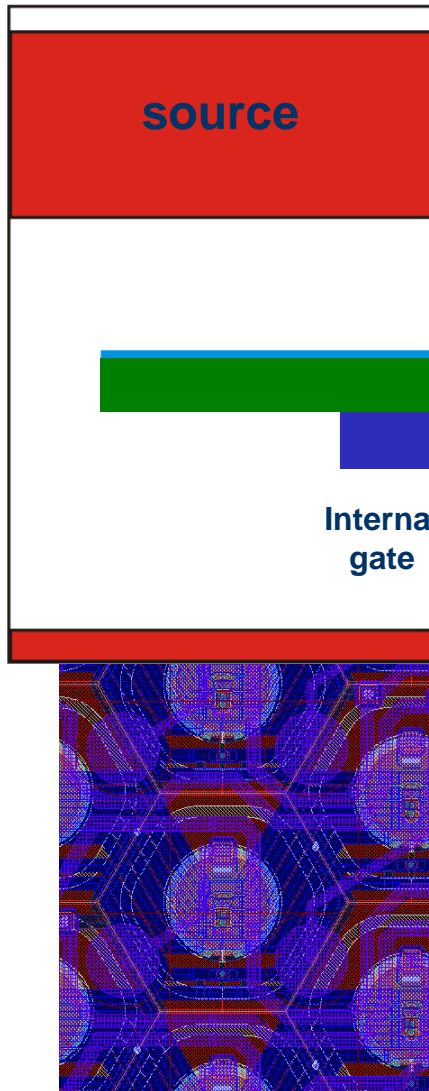
AGIPD (pixels)



... another approach ... non-linear DEPFET

Matteo Porro

gate



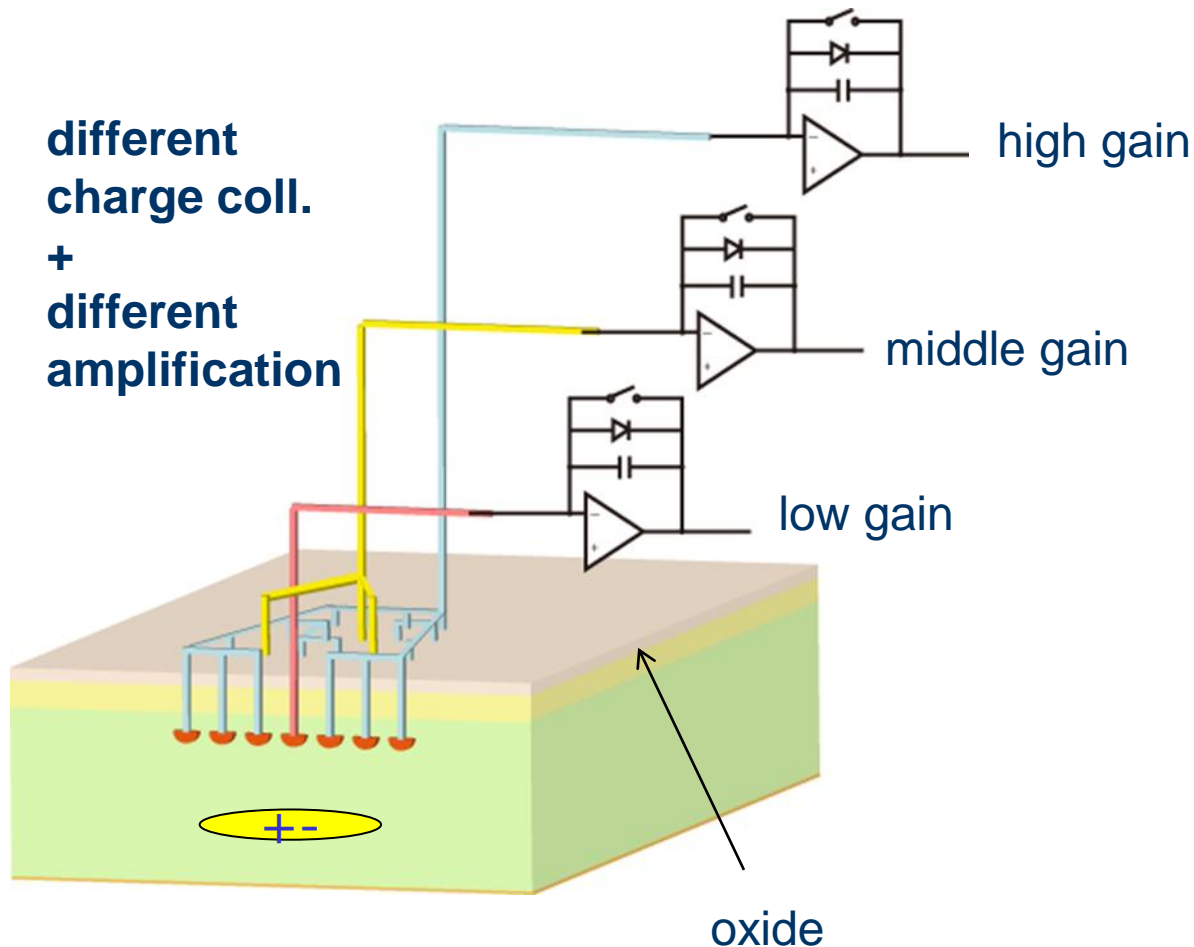
ready
2015

... towards free electron laser ... addressing 10^5 dyn. range

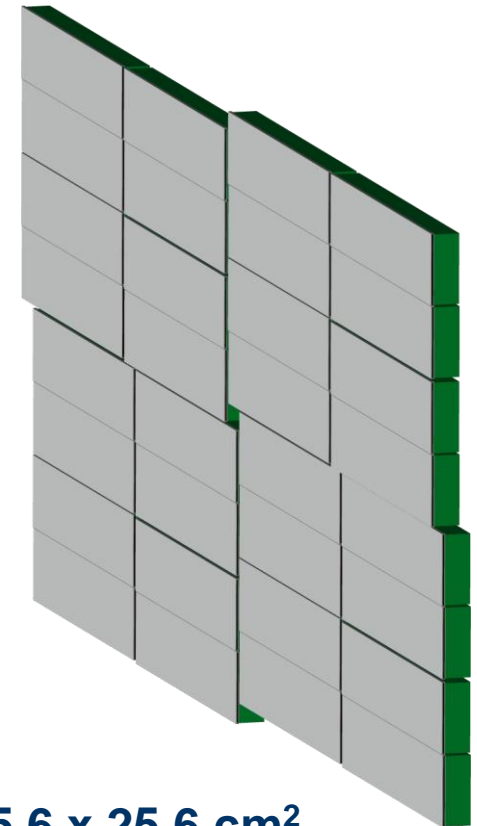
Takaki Hatsui

multi via approach with different gains using SOI technology

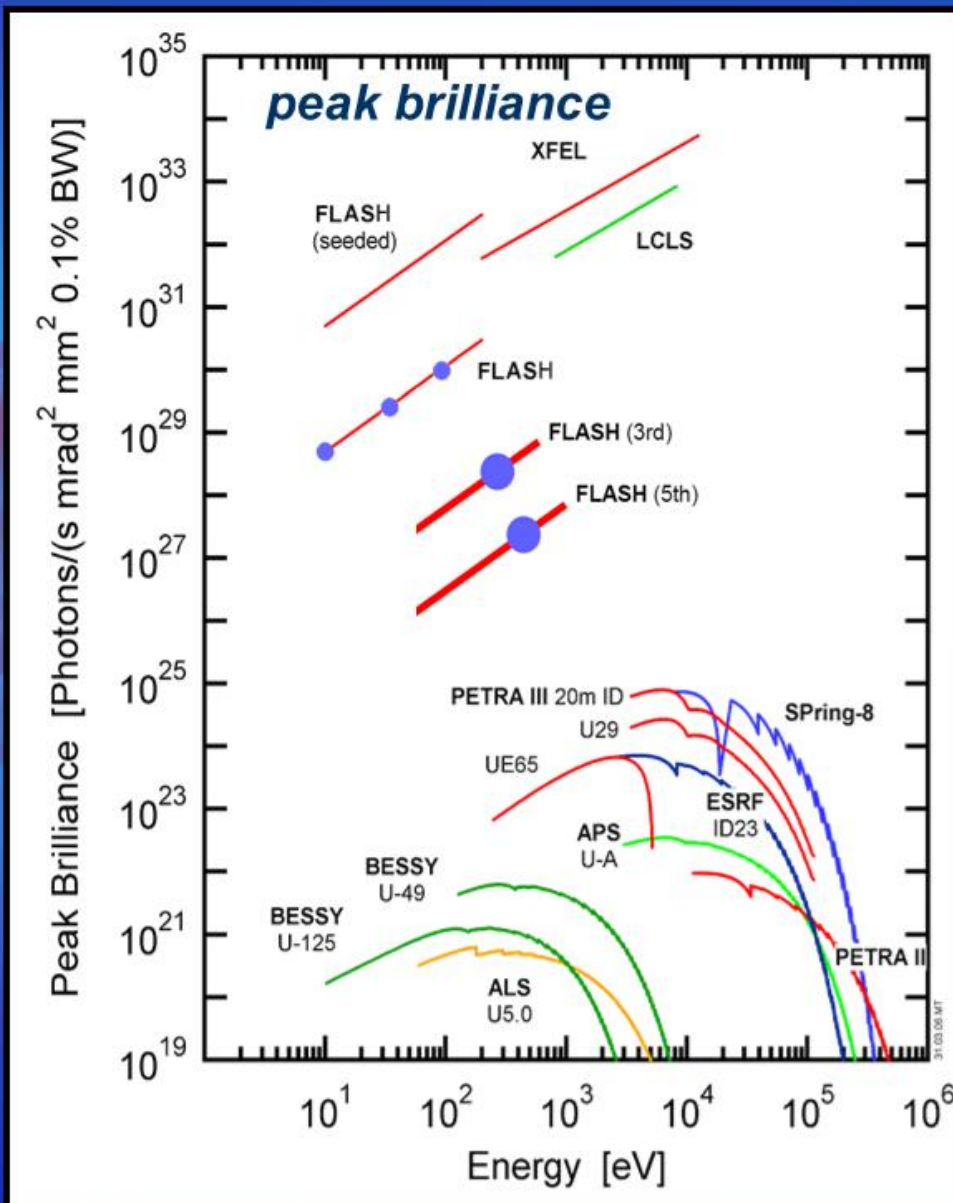
**different
charge coll.
+
different
amplification**



goal: 5.1 kpix x 5.1 kpix array



Xray – FELs ... a world wide effort



- **FLASH: 2005**
- **SCSS: 2008-10**
- **LCLS: 2009**
- **FERMI: 2009**
- **XFEL: 2013**

Lothar Strüder



Free Electron Lasers

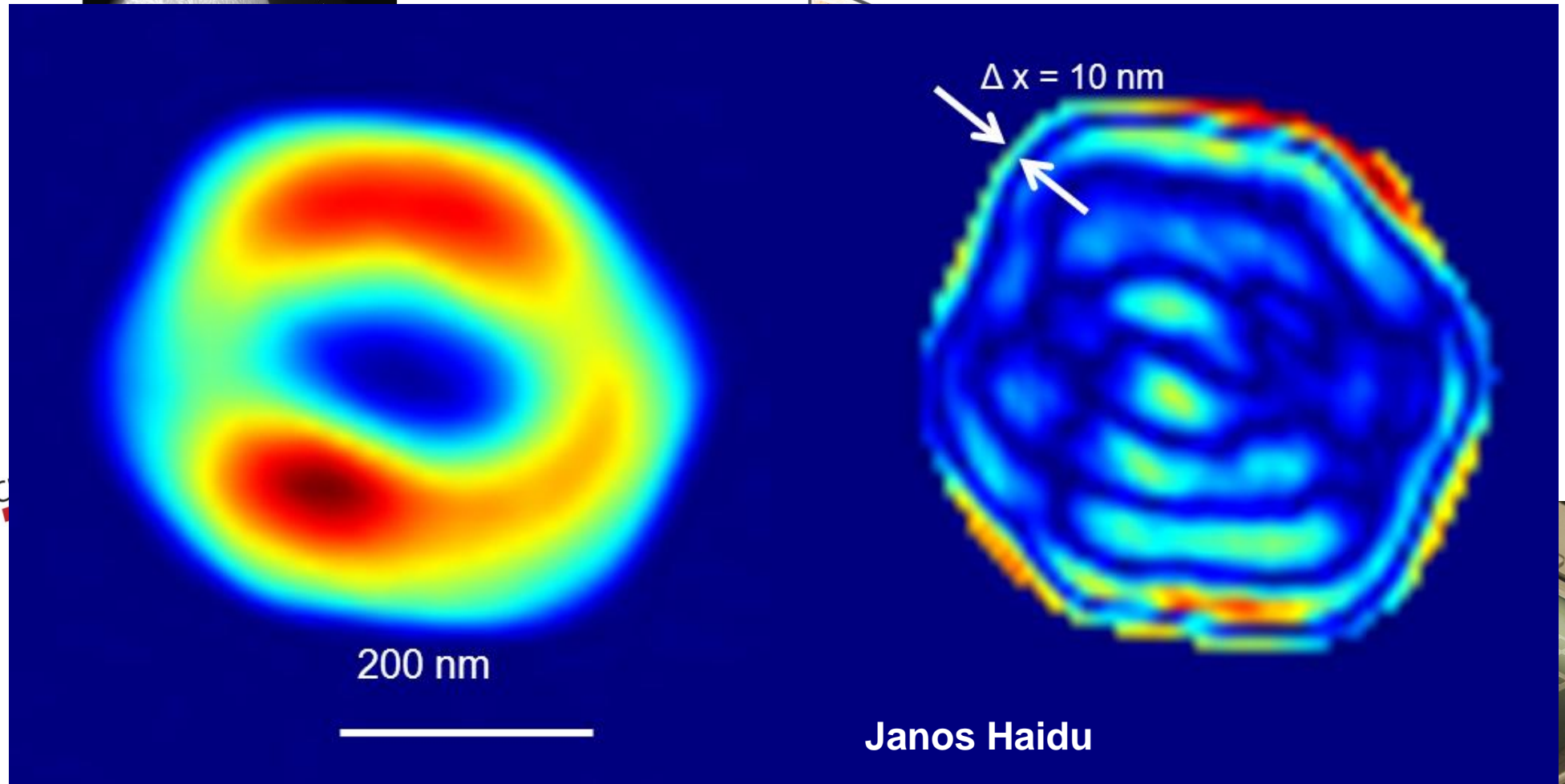


...across the classical disciplines
...across institutions



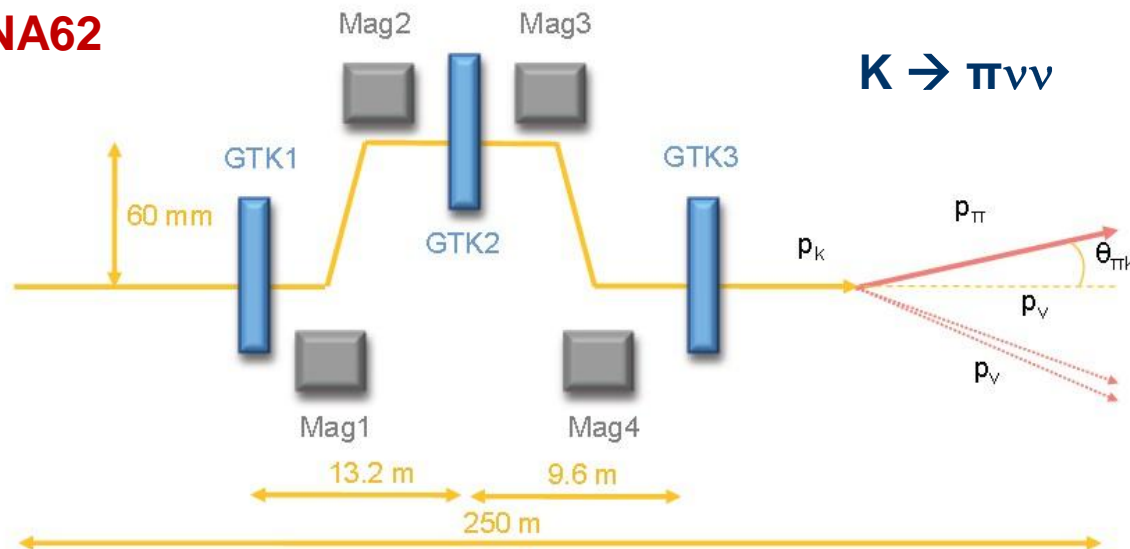
CFEL: 350 people
UHH + DESY + MPG

First measurements at FLASH. LCLS



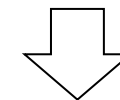
Some fancy new chips for dedicated applications

NA62

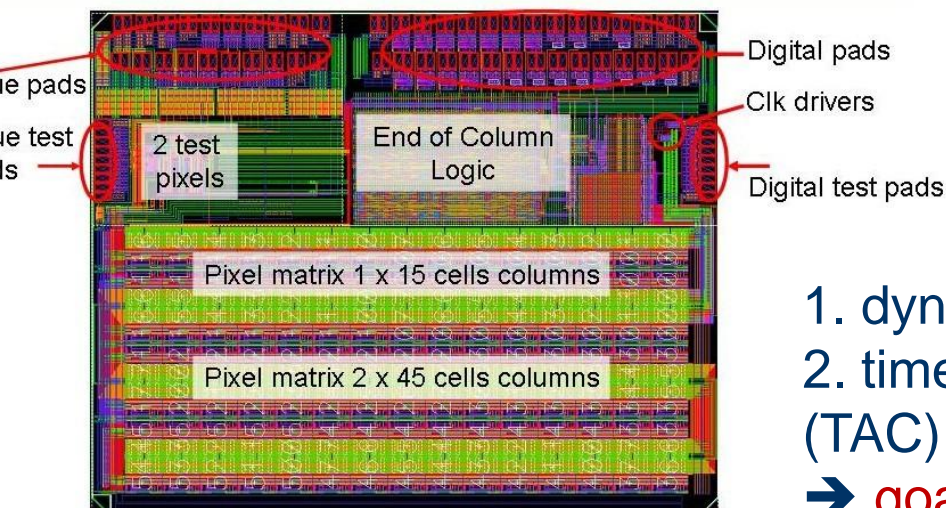


Giulio Dellacasa

a very rare decay experiment (10^{-11})



intense beam
measure very cleanly
→ excell. space resol.
→ excell. time resol.

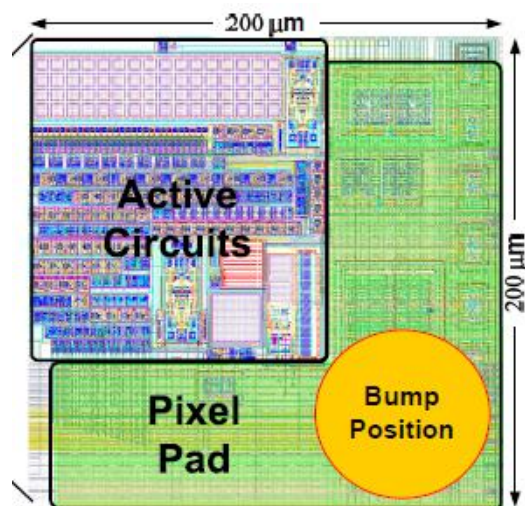
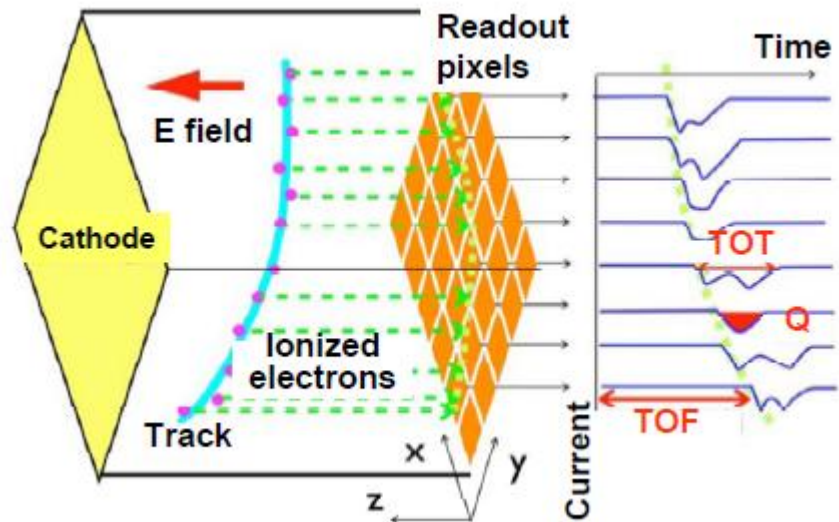


1. dyn. range requires time walk compensation
 2. time information via „coarse“ (count) → „fine“ (TAC) measurement
- goal $\sigma_{\text{time}} = 200 \text{ ps}$ (so far on track)

some fancy new chips for dedicated applications

Qpix: x,y,time,Q

Fei Li



similar function as
TIMEPIX

but for **> 10 fC**
and **10 Msps ADC**

Applications of the universal Timepix chip

Timepix study for e/γ discrimination
e.g. for dosimetry

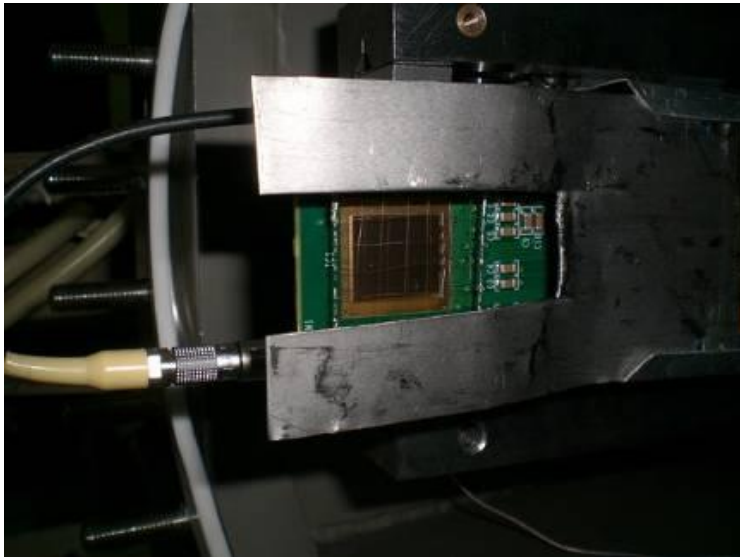
Cécile Teyssier



Timepix Metal Detector

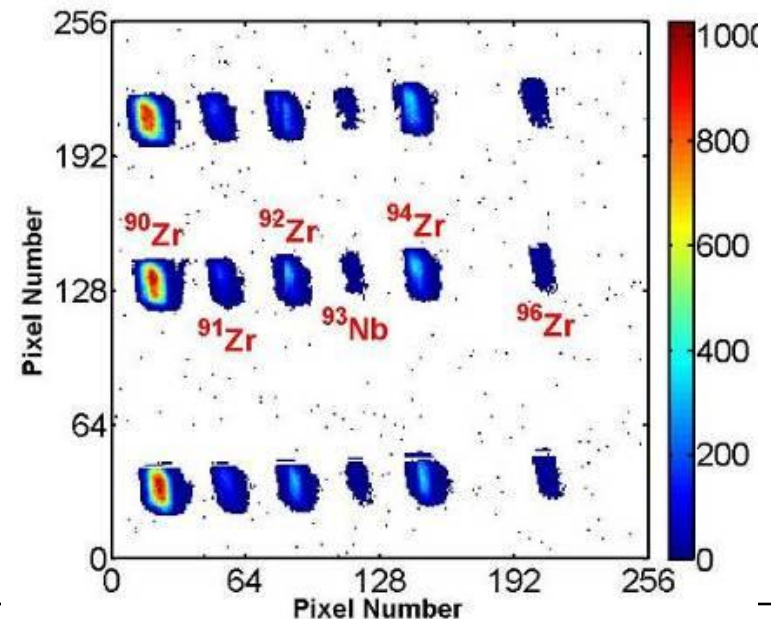
(no Si but mesh in front of electrodes)

ions grate electron plasmons external field pulls them out leaving induced charge on amplifier input



Valery Pugatch

use for ion beam tuning



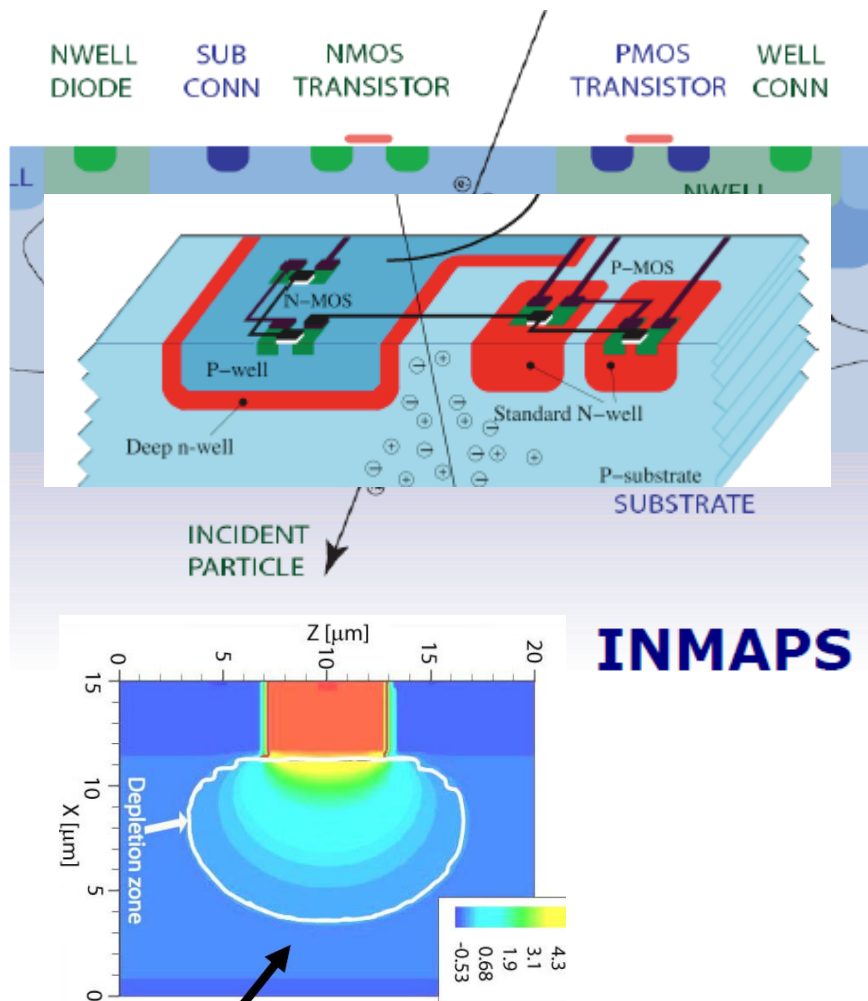
What's new on Monolithic Pixel Sensors ?

Monolithic active pixels (MAPS) ... „all in one device“

- in principle ... „the dream of a detector physicist“
- developed since 1998 ... matured as devices for detectors (e.g. STAR ... SuperB)

A. Dorokhov

G. Rizzo



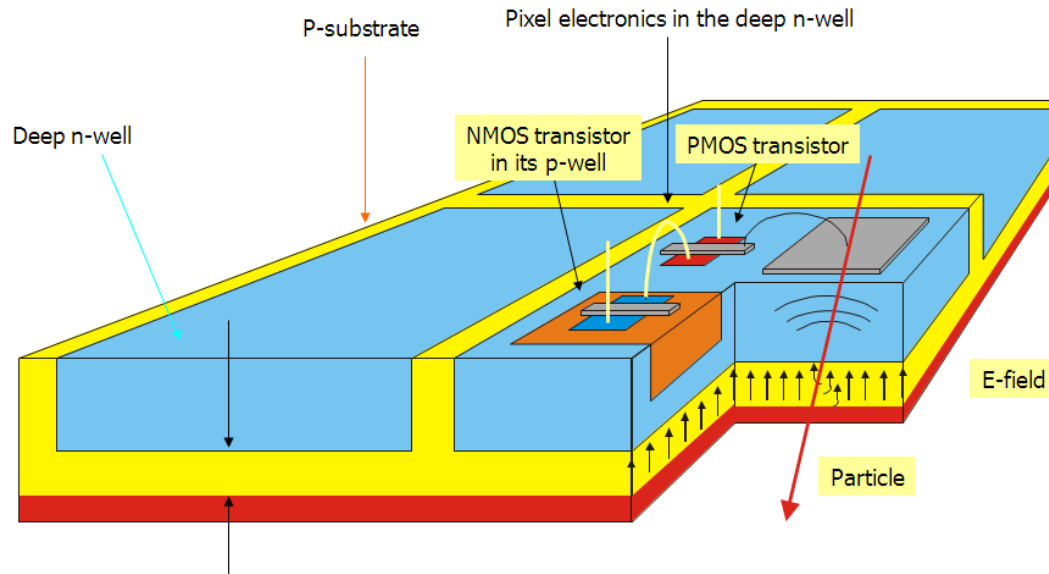
some problems/challenges addressed:

- (1) only nMOST in active area, no pMOST
 - triple well process → large deep nwell for Q-collection, pMOST outside (Luigi Gaioni → 65nm, Giuliana Rizzo)
 - shield PMOS-nwell by a pwell (quadruple well process) (Marcel Stanitzki)
- (2) radiation hardness → don't use for LHC
- (3) small signal and Q-collection by diffusion
 - larger coll. diode
 - higher resistance → higher Q-coll. eff. (Andrei Dorokhov, Marcel Stanizki)

this also improves rad. tolerance x100
→ good progress, e.g. S/N ~ 90 (M.S.)

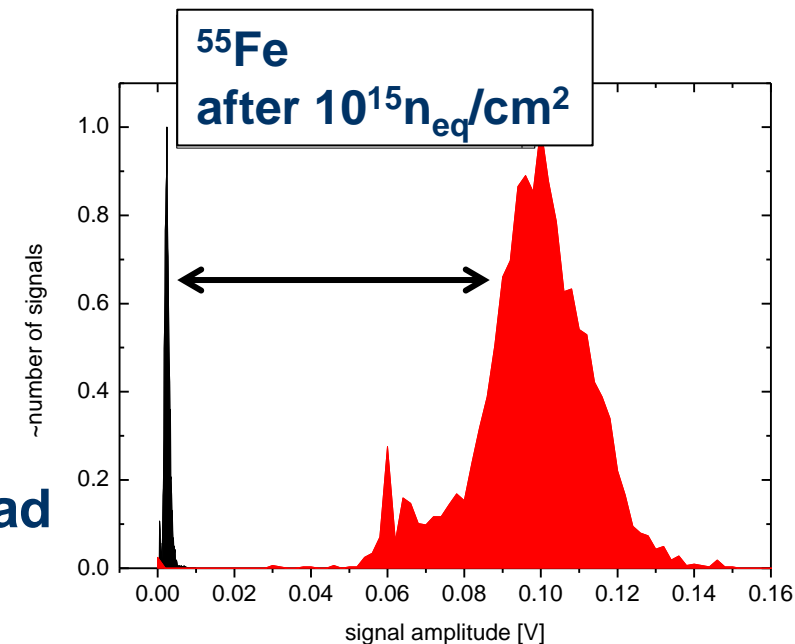
... new MAPS in HV technology (0.35 AMS)

Ivan Peric



- all electronics in same deep n-well
- Q-coll. in depl. volume by drift in E

- full CMOS
- ~full charge collection efficiency
- high S/N (~100)
- small pixels ($21 \times 21 \mu\text{m}^2$)
- fast
- radiation hard to $10^{15} n_{\text{eq}} / \text{cm}^2$ or 300 Mrad
- $(3 + 8) \mu\text{W} / \text{pixel}$



The diagram illustrates the layered structure of a CMOS image sensor. From top to bottom, the layers are: Electronics, BOX (Buried Oxide Layer), and Substrate. The Substrate is labeled as the Sensor. The structure includes n+ and p+ regions, PMOS and NMOS transistors, and a central pixel area. A dashed line labeled '放射線' (Radiation) indicates the incident light. Arrows show the movement of charge carriers (electrons and holes) within the substrate. A battery symbol is shown on the right, connected to the substrate.

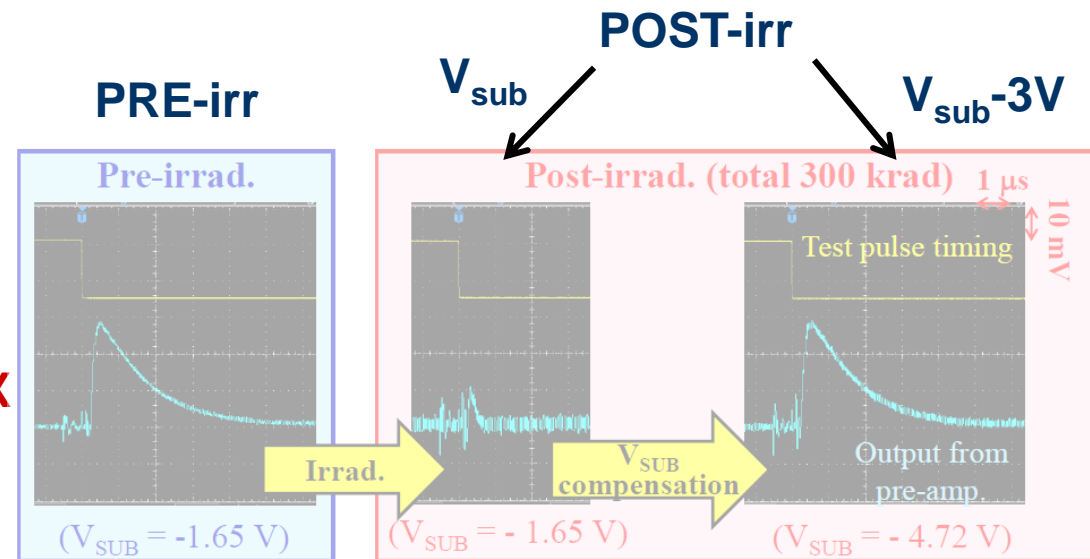
**“much progress with
OKI technology (200 nm)”**

R&D on e.g. ...

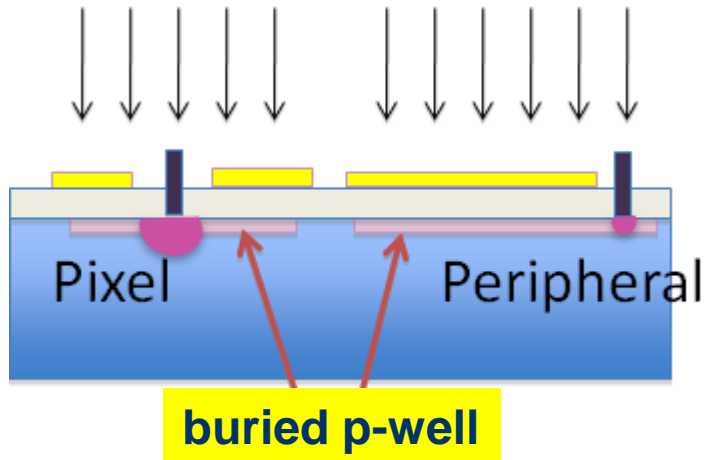
- **back side effect**
- **thin wafers $\rightarrow 110\text{ }\mu\text{m}$**
- **resistivity**
- **rad. hardness (c.f. BOX)**

hole trapping in BOX

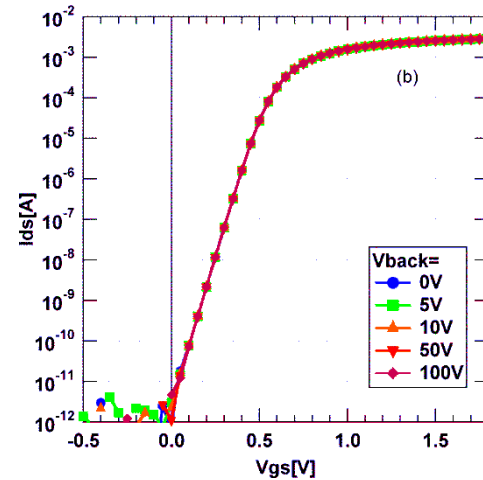
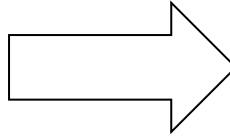
Yutaro Sato
Yasuo Arai



... the other important monolithic approach ... **SOI pixels**

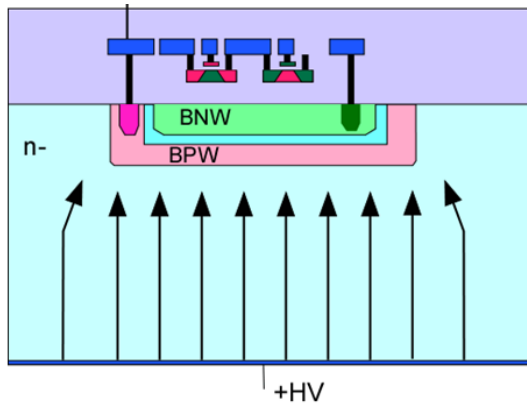


Y. Arai

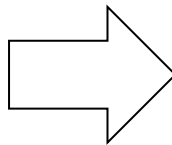


backside effect gone

no threshold shifts observed

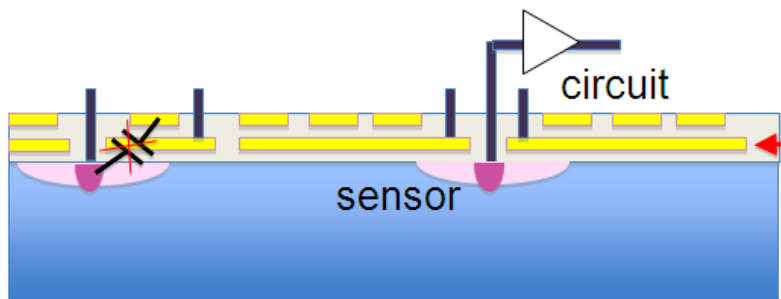


nested wells

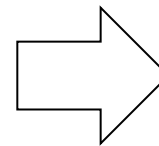


Q-coll. vial p-well
back gate and x-talk shielded by n-well

G. Deptuch, R. Yarema, Y. Arai

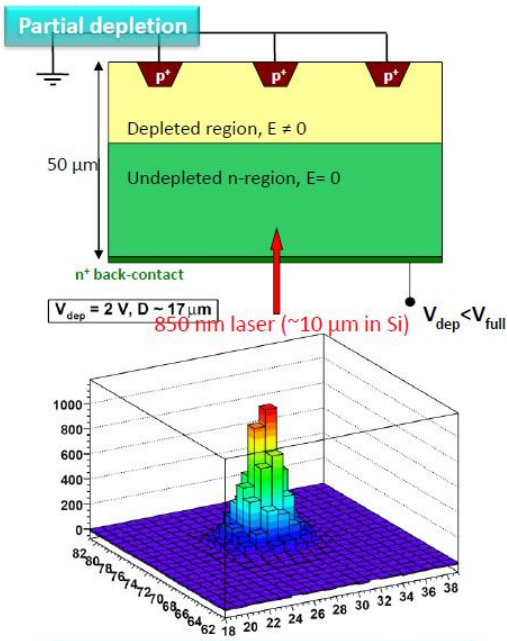


double SOI

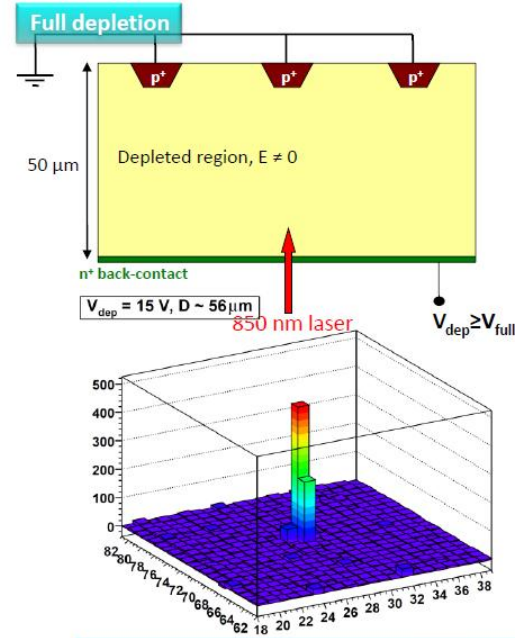


shield sensor area from circuitry

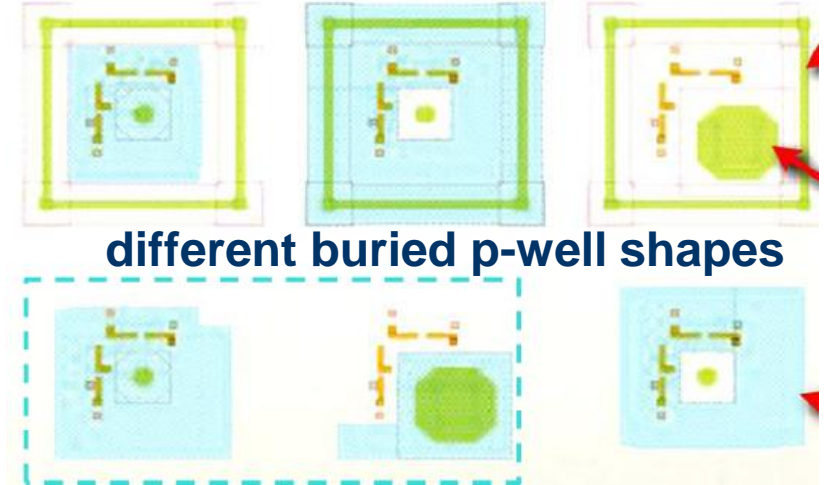
... the other important monolithic approach ... SOI pixels



half depletion



full depletion

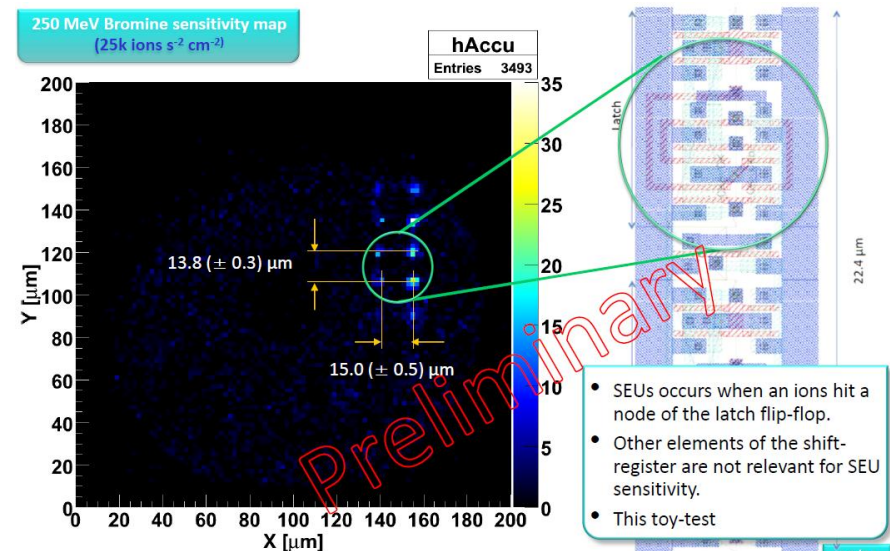
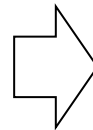


study full depletion and back gate effect

Piero Giubilato

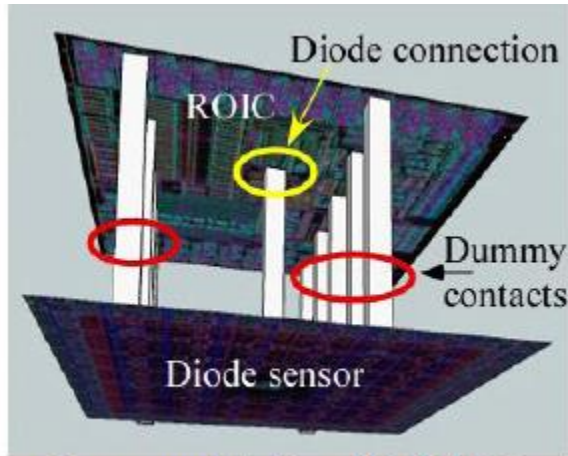
particularly impressive

tracing of the transistor
responsible for SEU



... 3D integration ... needs a long staying power

Ray Yarema



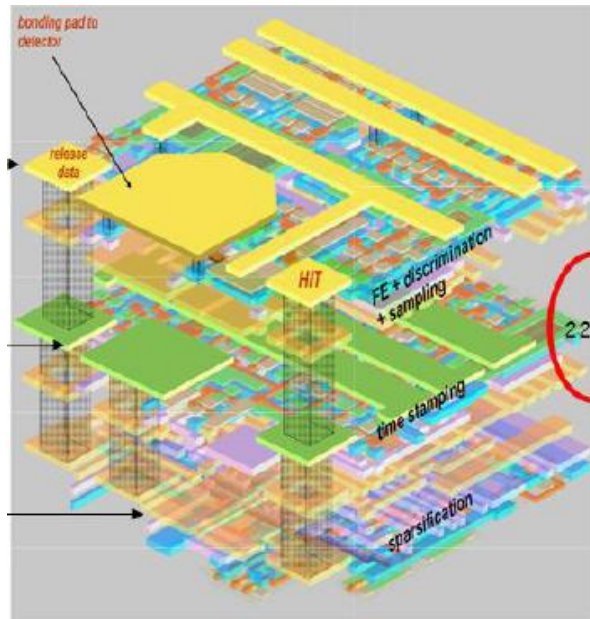
3D assembly for MAMBO3

Mambo3 (44x44 pix) (OKI 200 nm)

**finally 3D assembled (vias „last“)
from two chips on same wafer
by T-micro (talk Makoto Motoyoshi)**

**prototypes
with**

- OKI
- MIT LL
- Tezzaron/
Chartered



3 tiers in 1 block (MIT LL)

- **VIP1 ... many problems**
- **VIP2a ... so far encouraging**

Apologies to those whose work was not mentioned here ...

Mats Hollingsworth	Diamond Telescope
Anna Arbat	Geiger Mode APDs
Christian Brönnimann	DECTRIS
Gerhard Holst	sCMOS Chips (PCO AG)
Ralf Röder	CiS
Enver Alagoz	3D CMS
Makoto Motoyoshi	T-micron
Regina Moles-Valls	ATLAS ID Alignment
Frank Meier	CMS Tracker Alignment
Stefano Meroli	Grazing Angle Method

The Pixel Conference Series

WS on Semicond. pixel detectors (org. by E. Heijne)

- 1988, Leuven, 64 participants
- 1990, Leuven, 86 participants
- 1996 Bari, 100 participants

Pixel 2000, Genova, 84 participants

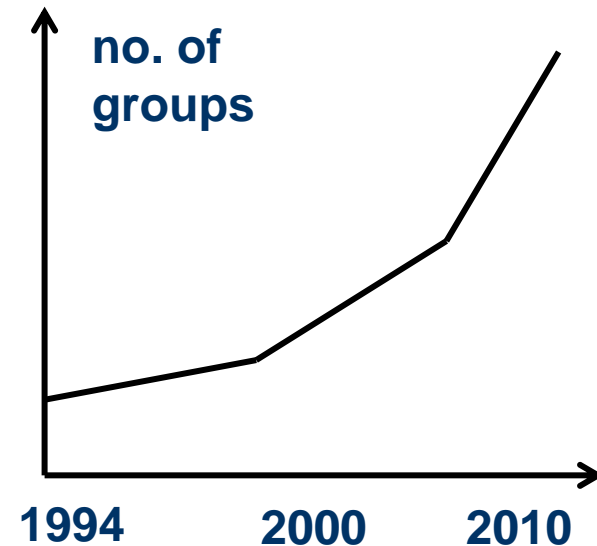
Pixel 2002, Camel, 55 participants

Pixel 2005, Bonn, 107 participants

Pixel 2008, Fermilab, 83 participants

Pixel 2010, Grindelwald, 93 participants

Pixel 2012, very likely in **Japan, → **2xx** participants**



... and ...



A big, big thank you
(esp. Andrey, Danek, Roland)

for the splendid organization
of this PIXEL 2010 conference
at Grindelwald

... and ...



A big, big thank you
(esp. Andrey, Danek, Roland)

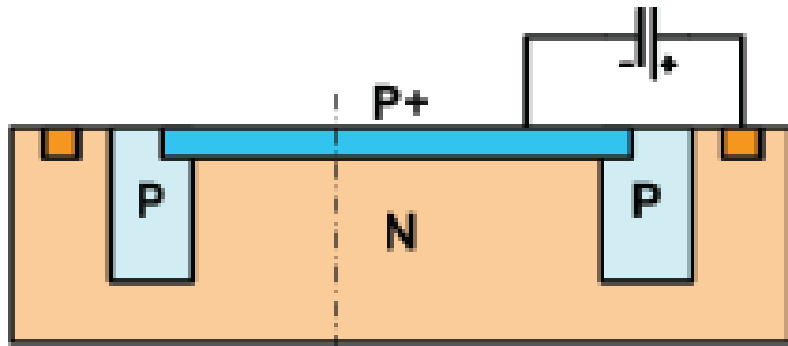
for the splendid organization
of this PIXEL 2010 conference
at Grindelwald

foto stolen from Nobu Unno

BACKUP SLIDES

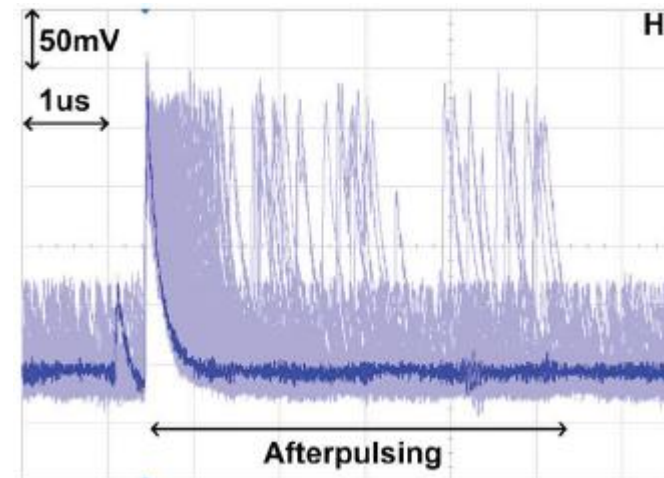
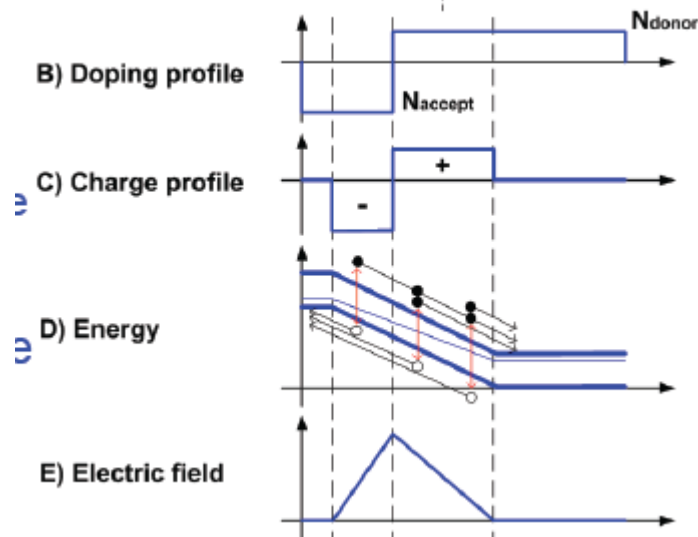
R&D for new detector types ...

Anna Arbat



pixelated Avalanche Photo Diodes
in Geiger mode

→ what to do with dark current
and afterpulses ?



designed 0.35 AMS-HV CMOS structure
with different quenching schemes

promising prototypes !

Monolithic active pixels (MAPS) ... „all in one device“

- in principle ... „the dream of a detector physicist“
- developed since 1998 ... matured as devices for detectors (e.g. STAR ... SuperB)

A. Dorokhov G. Rizzo

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